



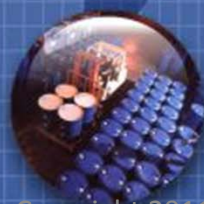
Cleaning Underneath BGAs

BEST Electronics Soldering Technologies

August 21, 2012



Providing In-Process Cleaning Chemistries
and Technical Services Worldwide



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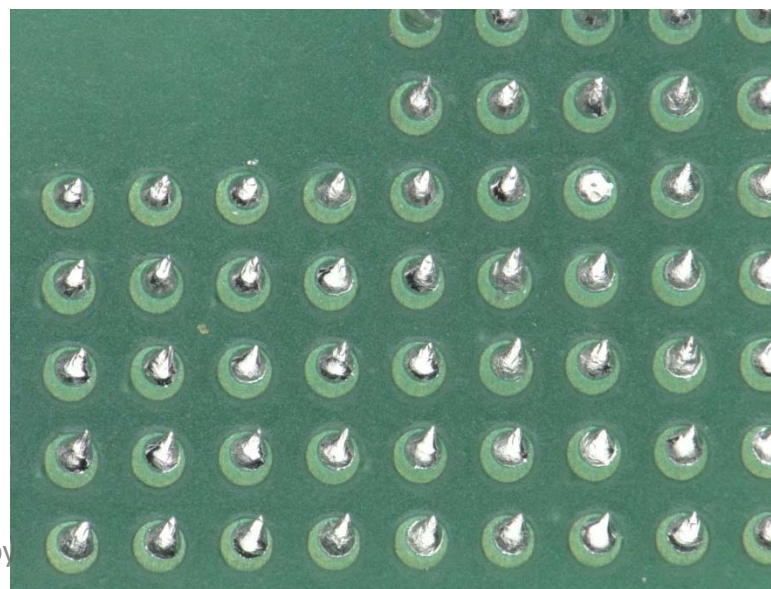
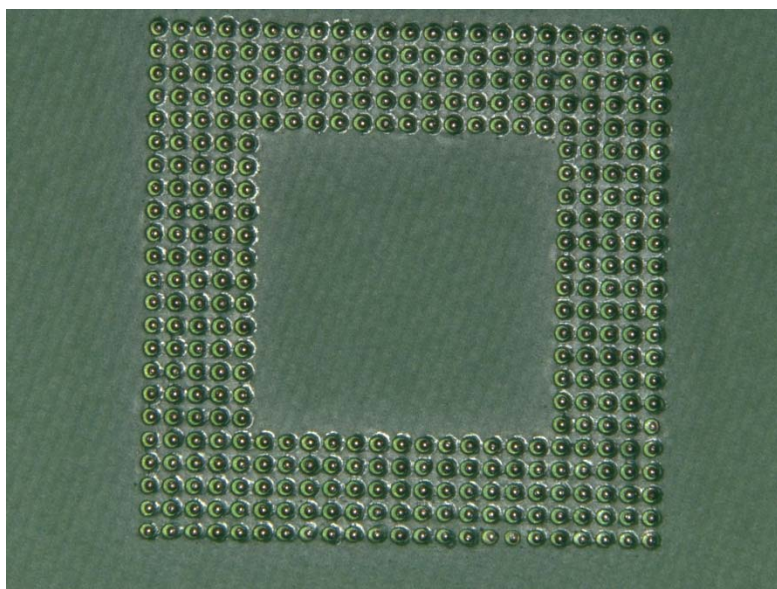
Agenda

- Introduction
- BGA Cleaning Considerations
- Designing the Cleaning Process
- Factors that Affect Cleaning
- Conclusions



Ball Grid Assemblies

- How clean is clean enough?
 - More challenging to answer as conductors and circuit traces are increasingly narrower
 - What is acceptably clean for one segment of the industry may be unacceptable for more demanding segments

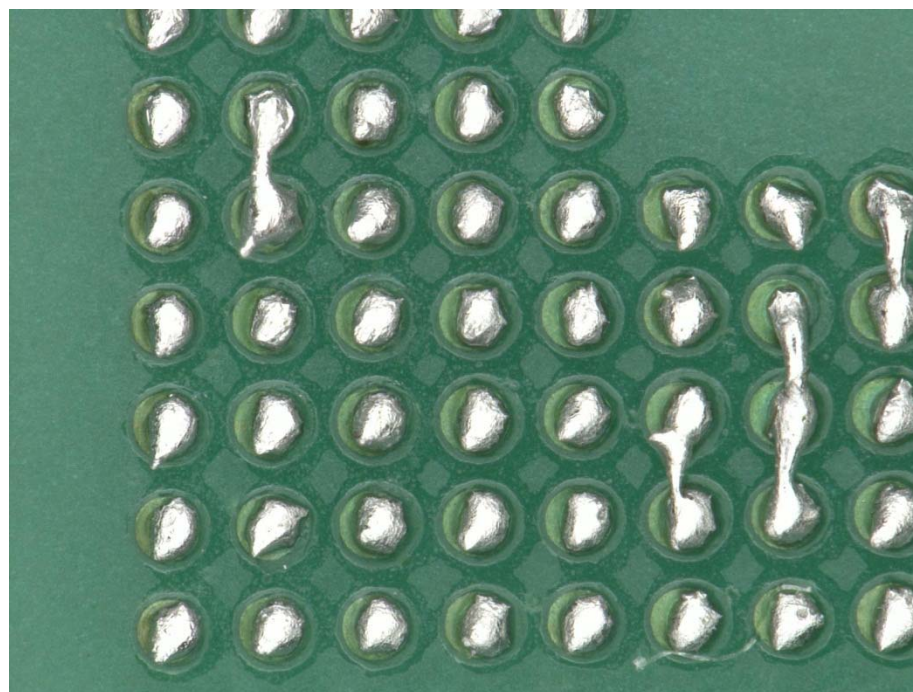


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Residues on BGAs

- May increase the risk of
Premature failure
Improper function





BGA CLEANING CONSIDERATIONS



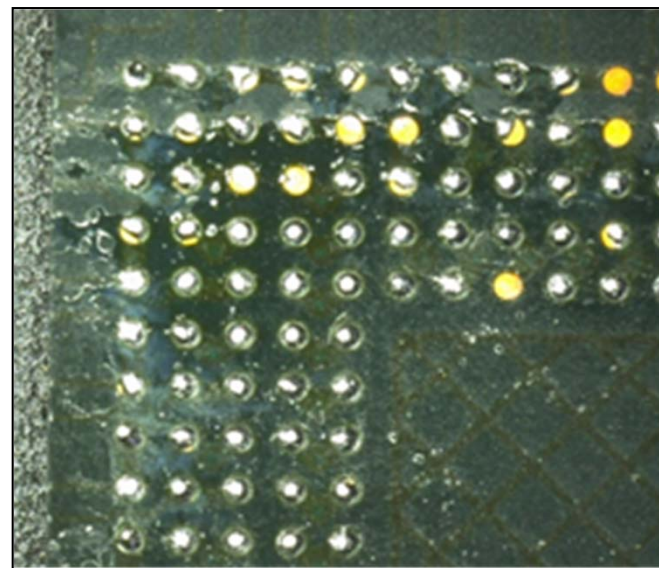
Technology Evolution

- Jobs needed to be done by products
 - Technology powered devices continue to miniaturize
 - More interconnects result in
 - Tighter pitch
 - Lower standoff (Z-Axis)
- Narrow distances between conductors requires
 - Higher levels of cleanliness



Z-Axis

- As the standoff height gap reduces
 - Flux residue capillary forces underfill device
 - Flux residues now bridge conductors
 - May create the potential for
 - Electro-chemical migration
 - Electro-migration



μBGA with 0.40 mm pitch



Factors to Consider

- BGA circuit trace width
- BGA standoff gap
- Solder Paste / Paste Flux Selection
- Package Placement
- Solder Paste Reflow (Heat Exposure)
- Solder mask definition
- Cleaning Agent
- Mechanical effects

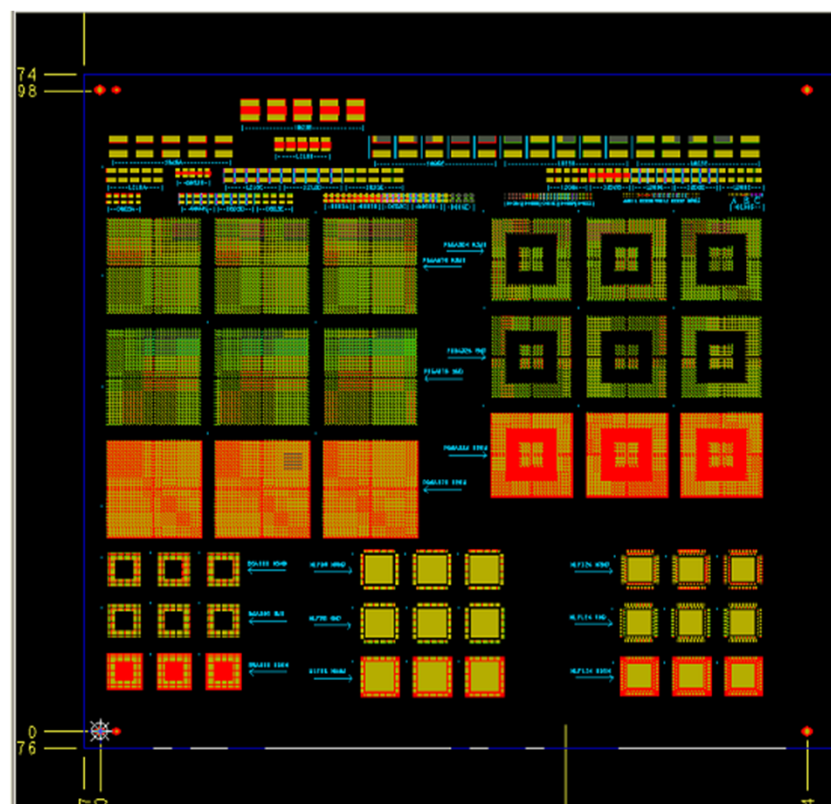


DESIGNING THE CLEANING PROCESS



Bottom Termination Components

- Layout influence the clearance gaps
 - Component selection
 - Solder mask definition
 - Placement

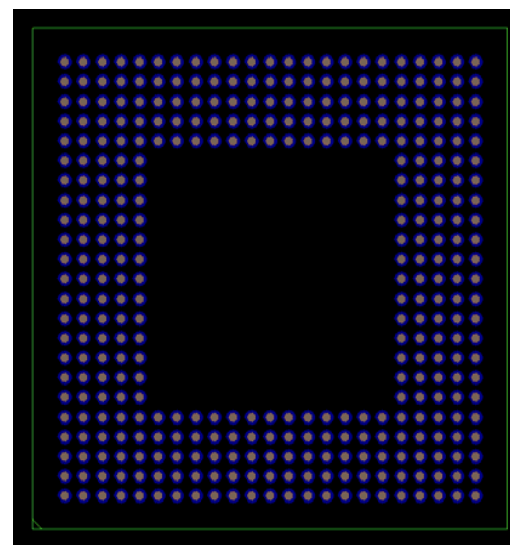
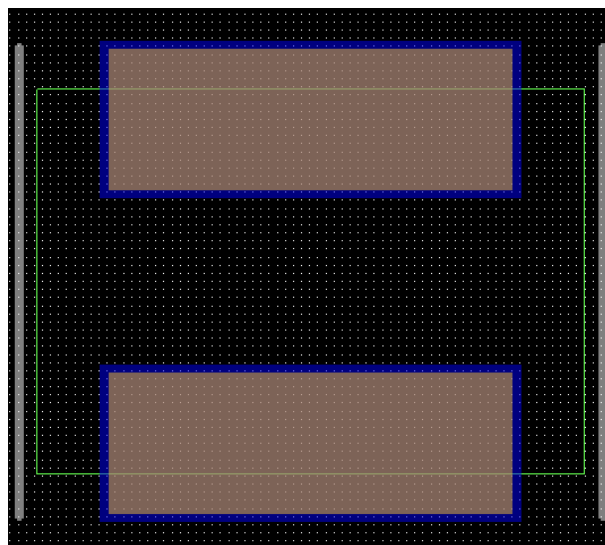


Plexus/Kyzen Clean Test Vehicle



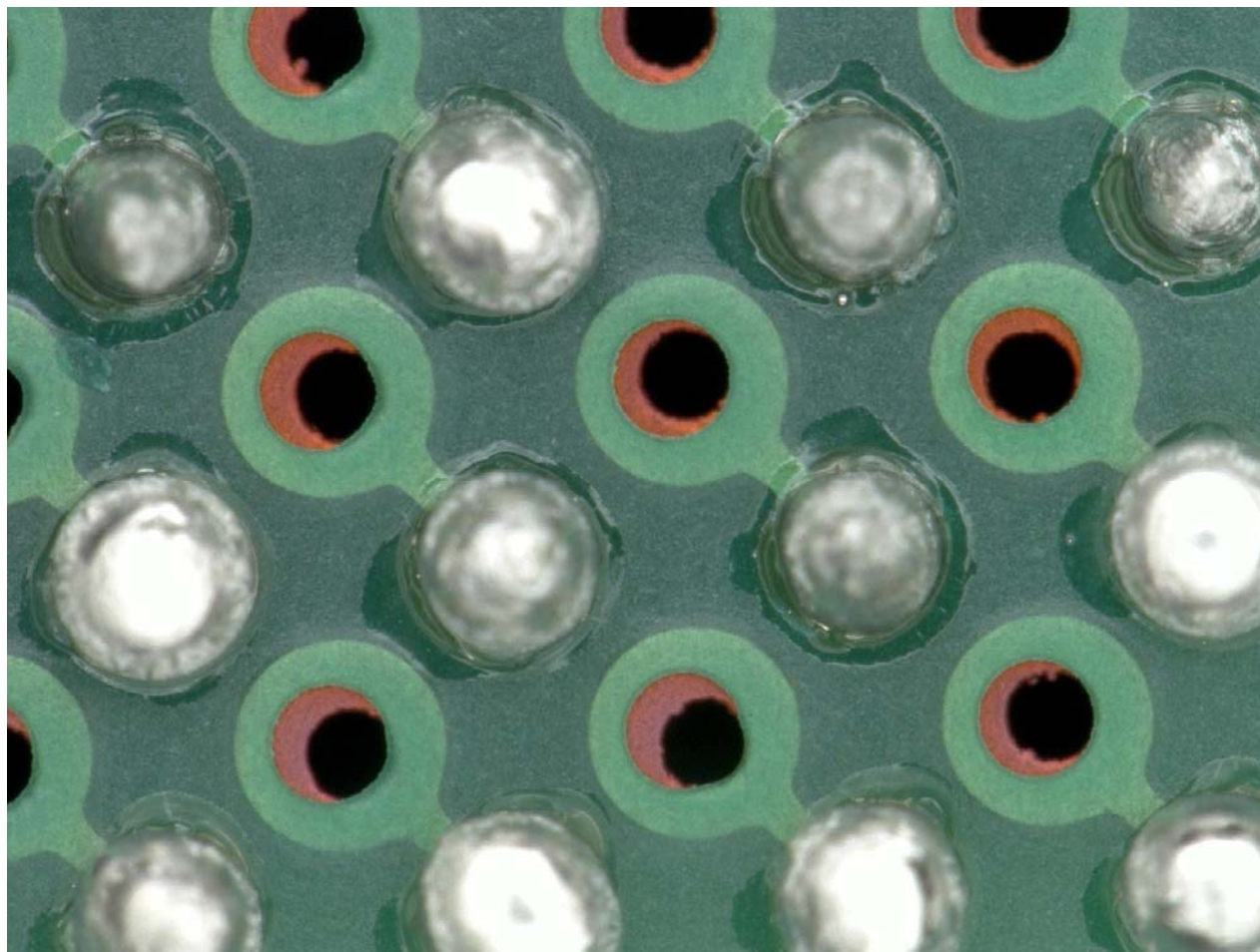
Solder Mask Defined Pads

- Very little preclearance on
 - Each side of the connection
 - 2-4 mils preclearance per side
 - Solder mask is present between pads





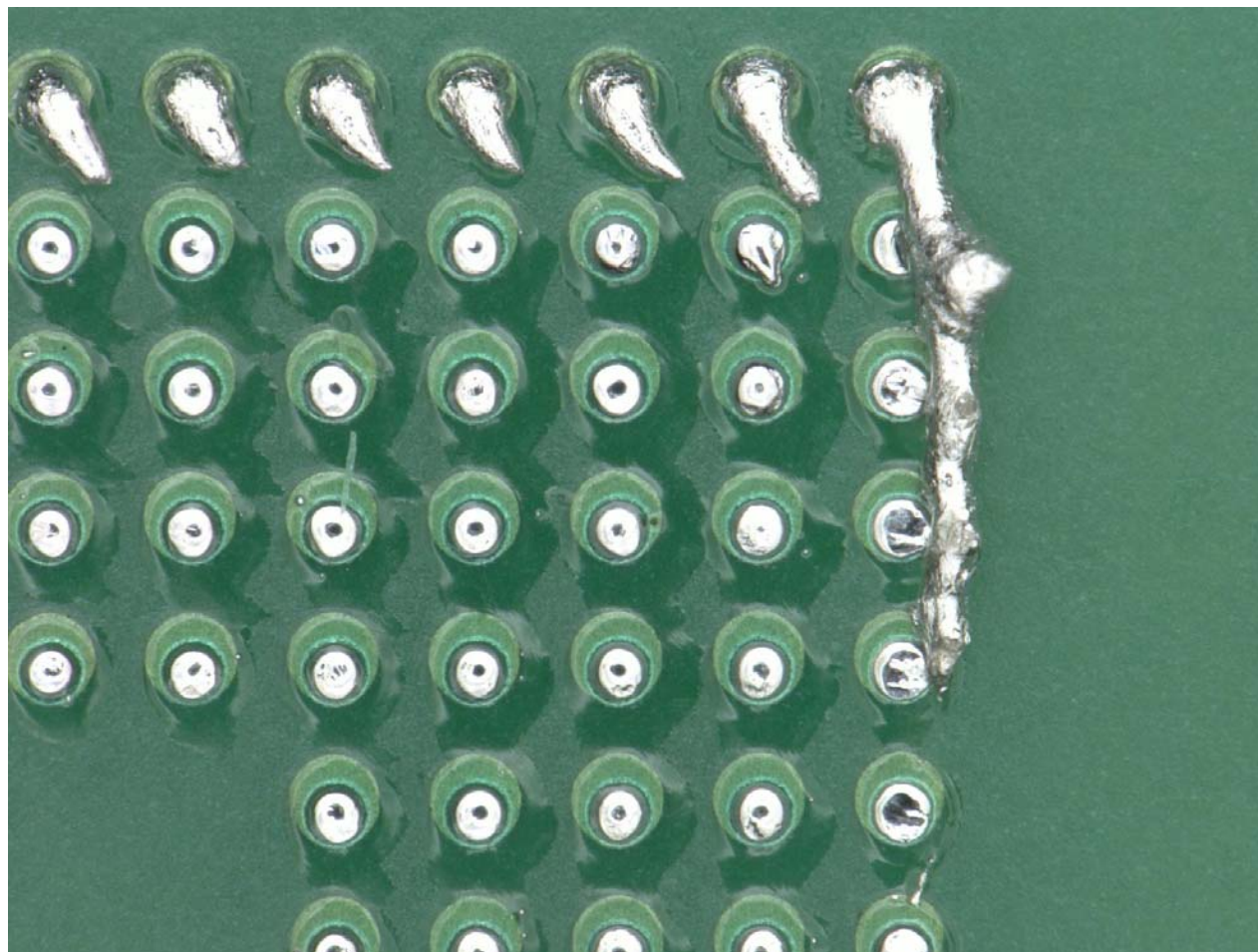
Solder Mask Defined



Wide Pitch



Solder Mask Defined

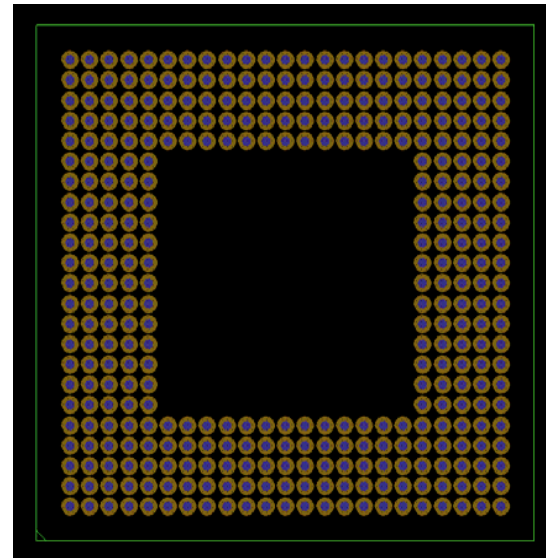
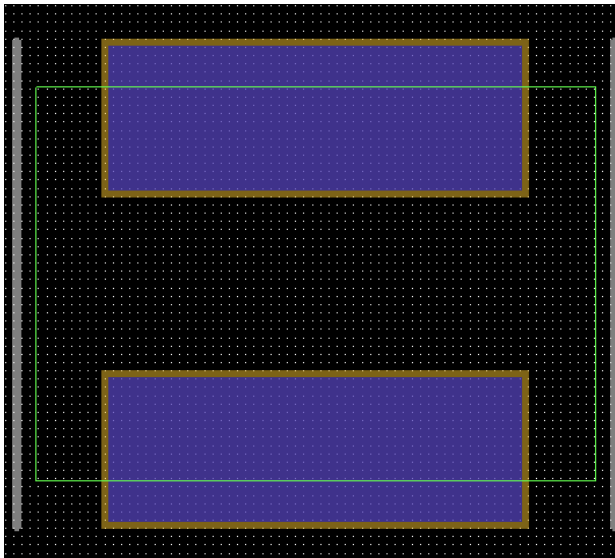


Narrow Pitch



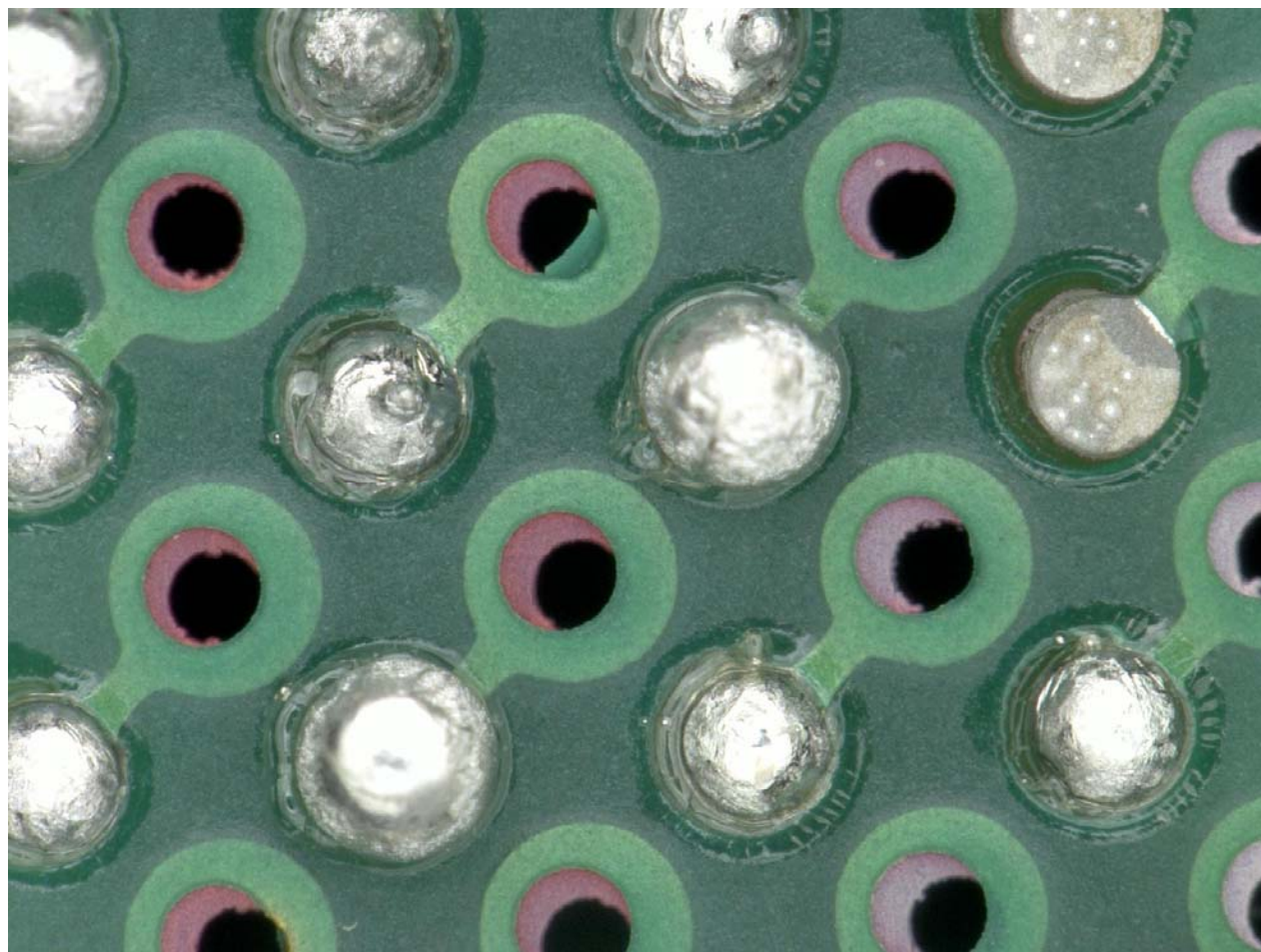
Non-Solder Mask Defined Pads

- Non-solder mask defined pads
 - Removes solder mask in the pad areas
 - Flux pools around component
 - Solder mask between pads





Non Solder Mask Defined



Wide Pitch



Non Solder Mask Defined

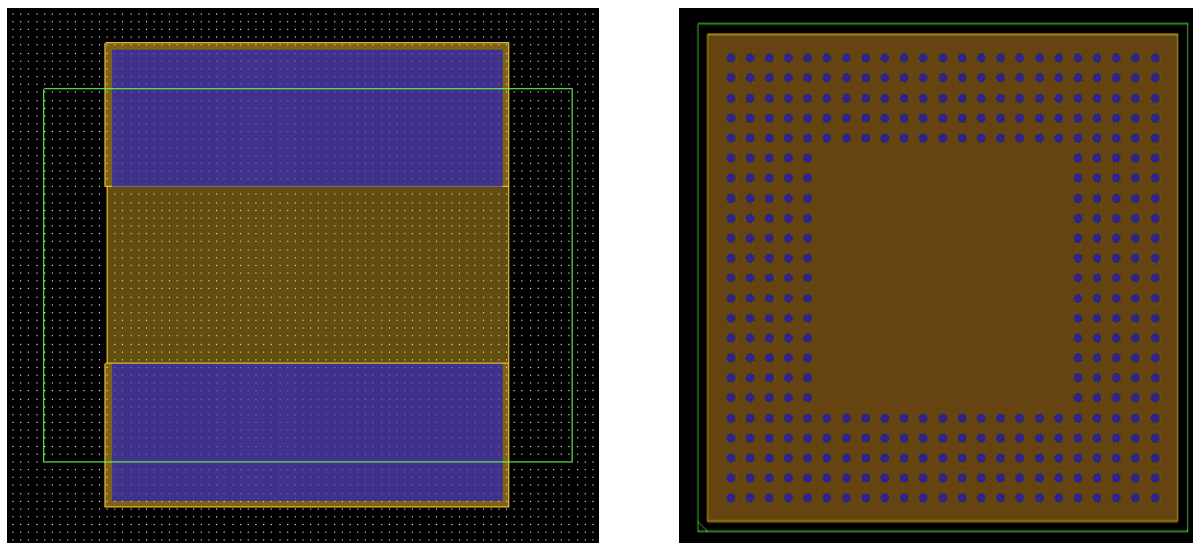


Narrow Pitch



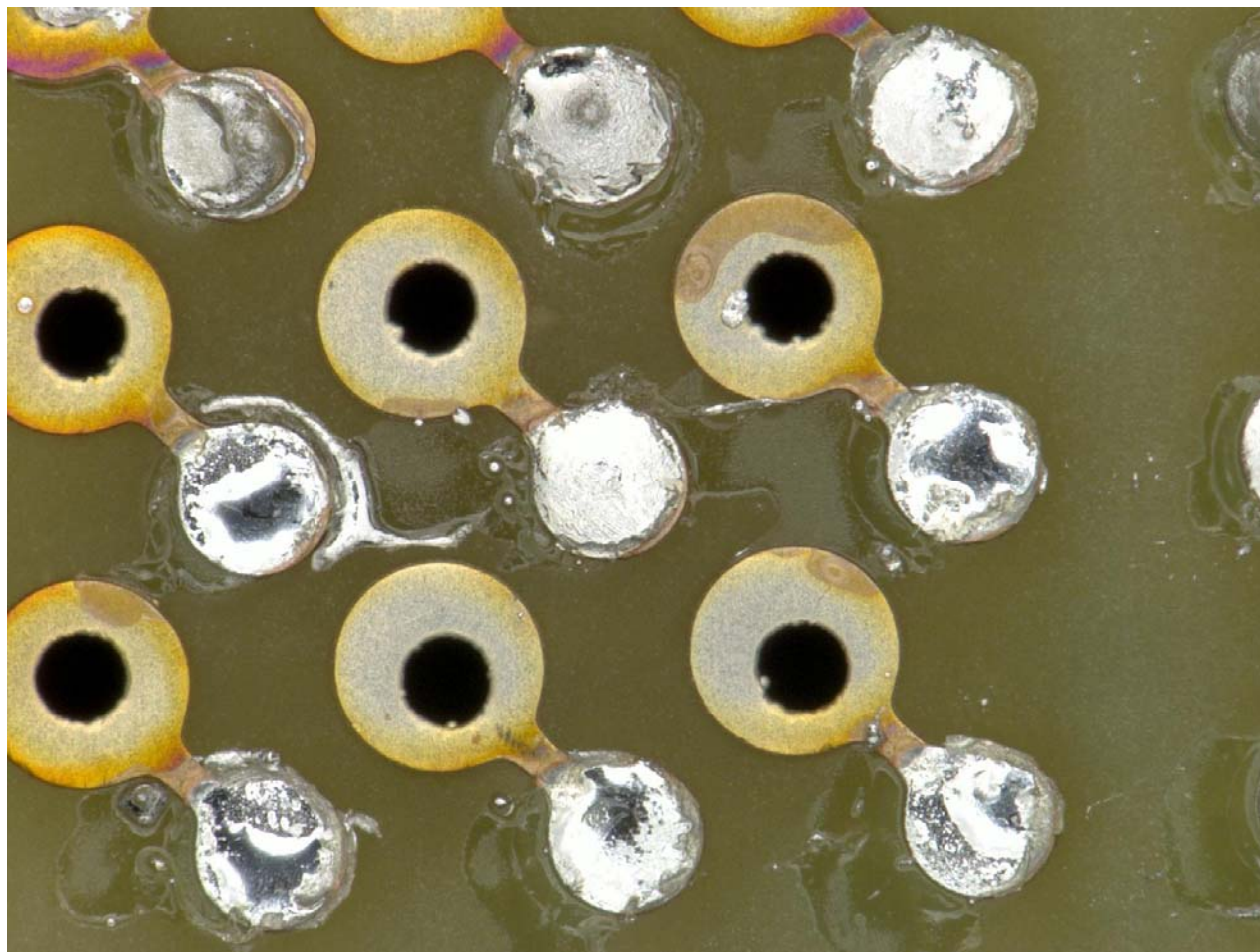
No Solder Mask on Pads

- Removes the solder mask in both
 - Pad area
 - Under the component
 - Increases the standoff gap





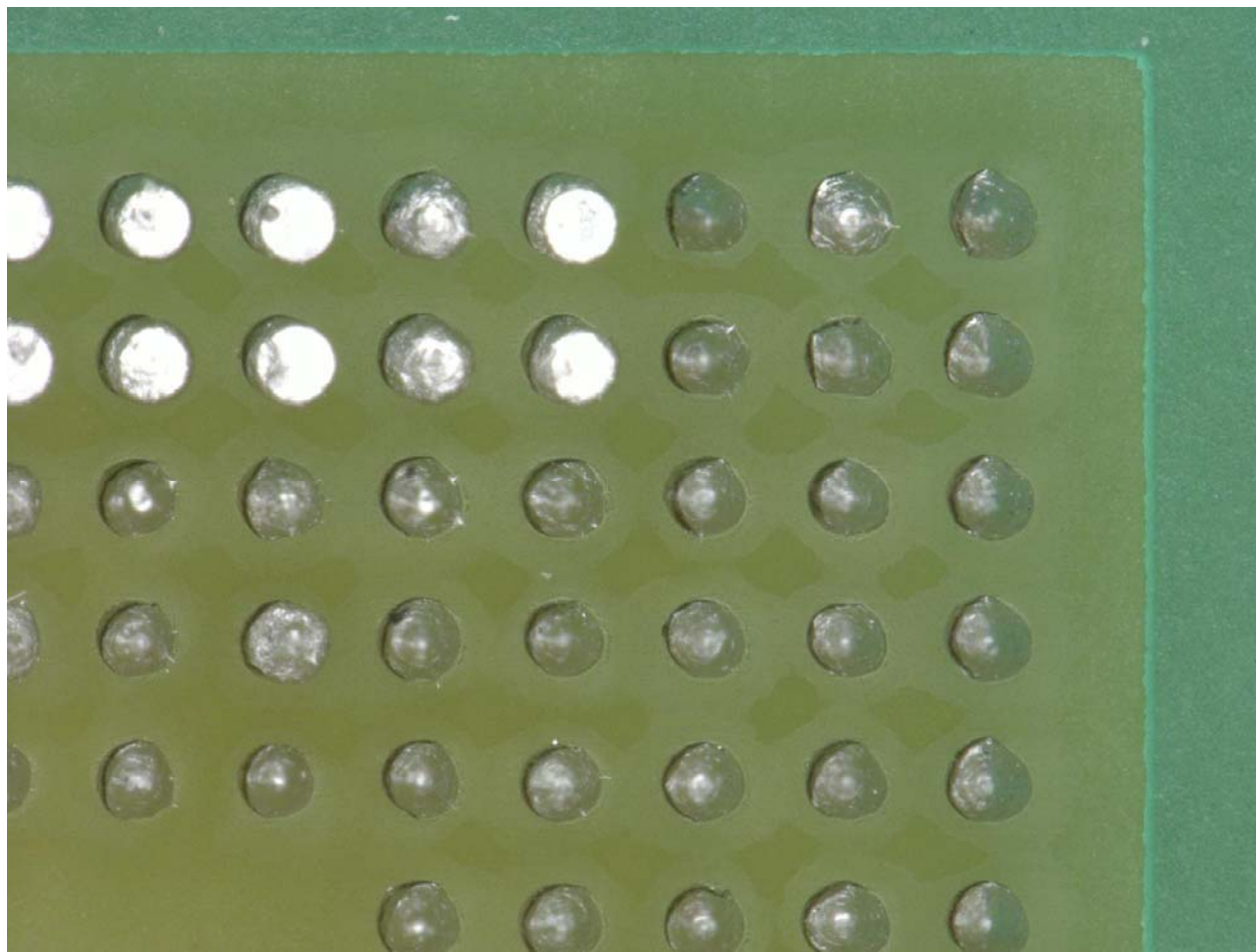
No Solder Mask



Wide Pitch



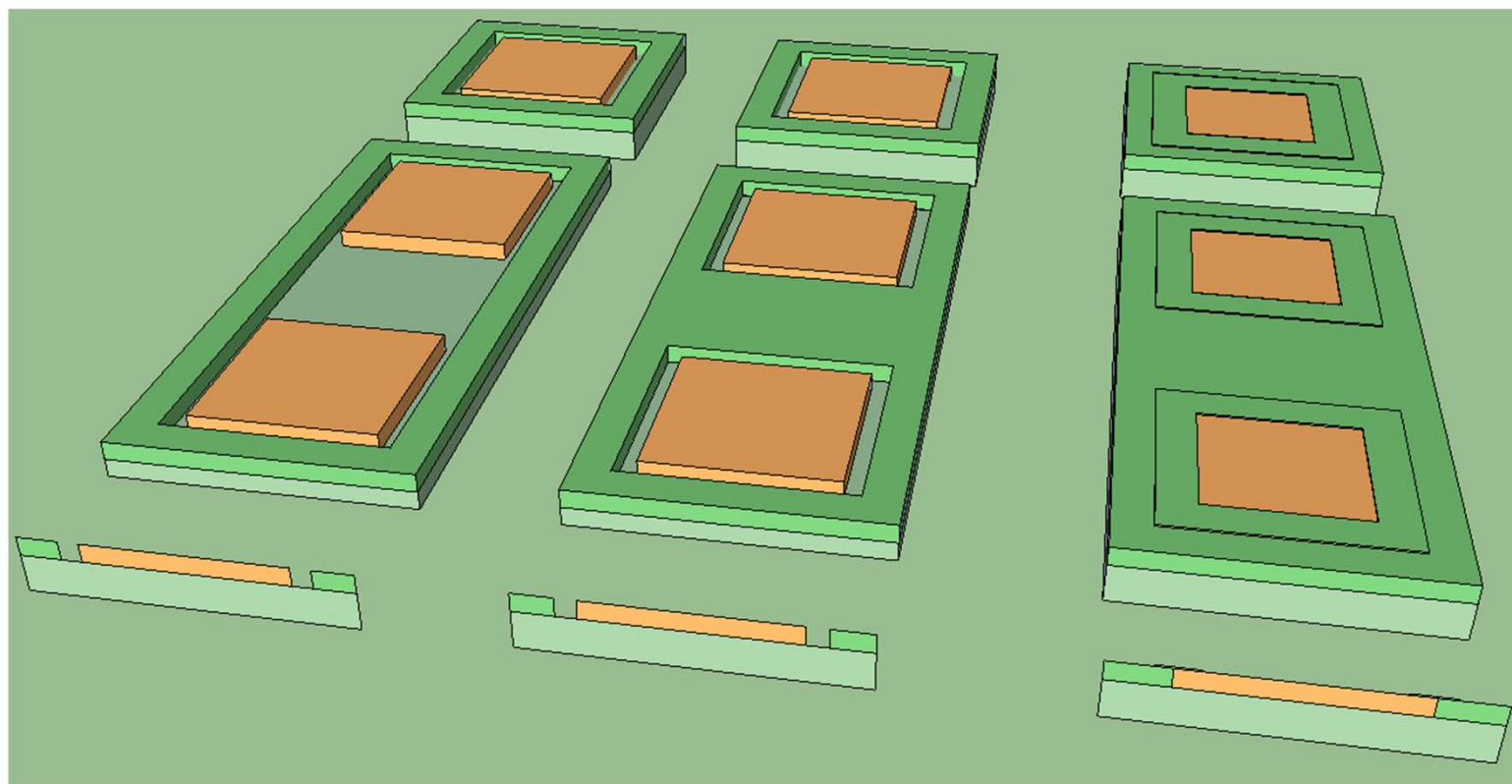
No Solder Mask



Narrow Pitch



SM Comparison

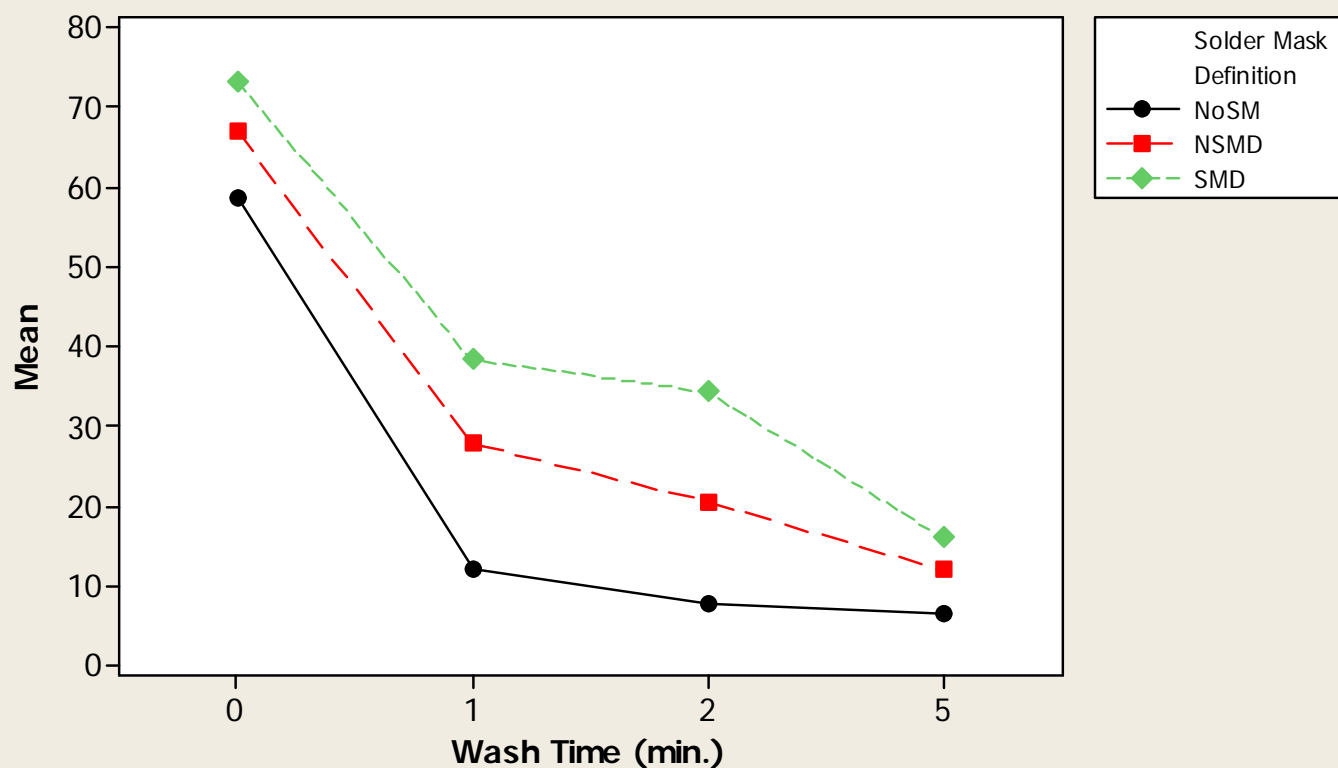




Cleaning Comparison Data

Interaction Plot for Z Axis BTC Cleaning for all Solder Pastes

Data Means





FACTORS AFFECTING CLEANING

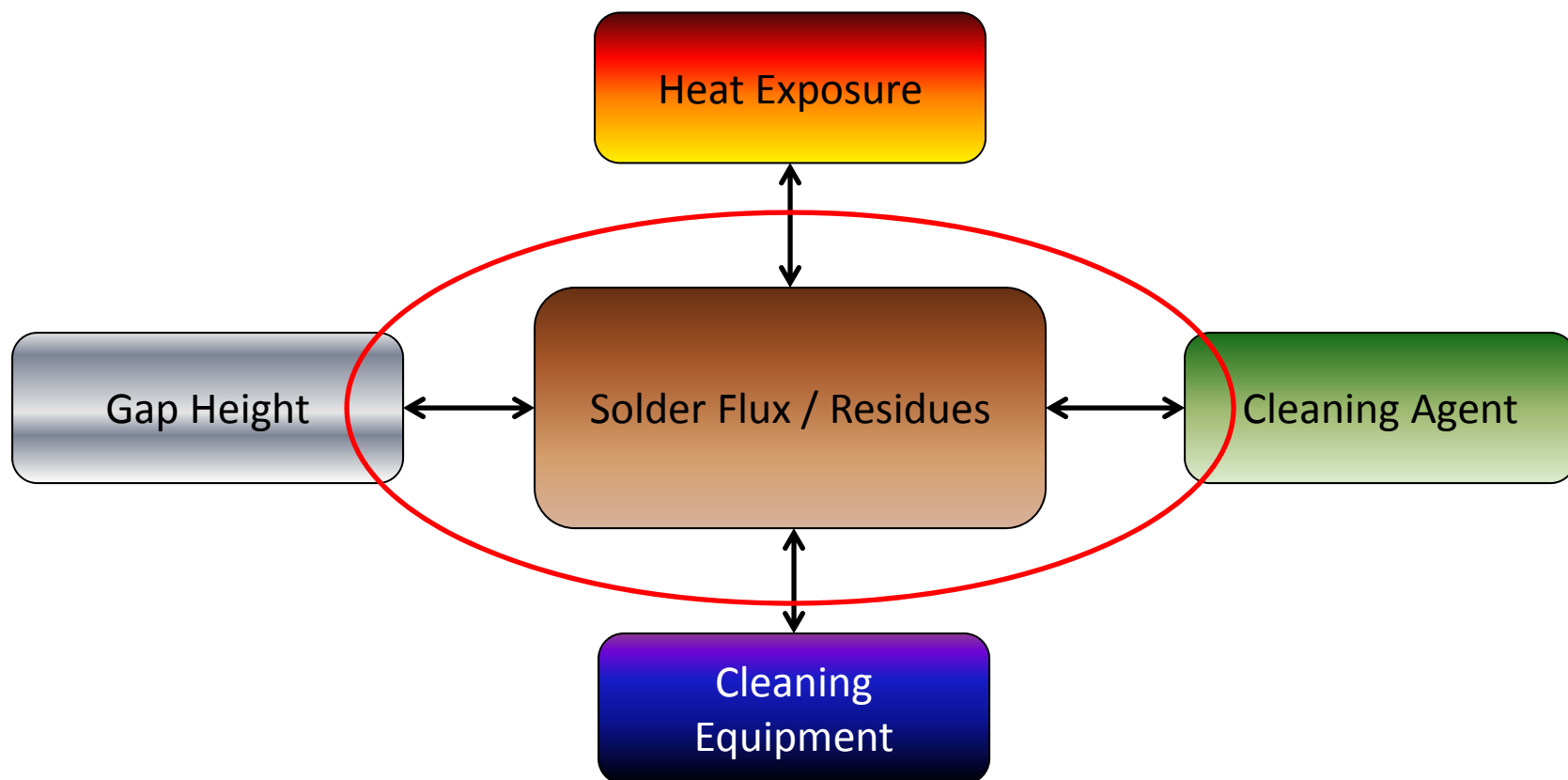


Cleaning BGAs

- To clean under component gaps with tight Z-Axis
 - Understand the nature of the soil
 - Optimize the soldering step
 - Increase gap height if possible
 - Select cleaning agent that matches up to the soil
 - Mechanical system to deliver cleaning agent to soil
 - Rinse step to remove soil and ionic contamination
 - Cleaning process that does not damage the part



Factors Affecting Cleaning





Soil

Alloys

- Eutectic tin/lead
- Lead free
- High lead

Flux Vehicles

- RA (rosin activated)
- RMA (rosin mildly activated)
- WS (water soluble)
- NC (No clean)

Each of these impact the nature of the residue

And what is required to clean it

Flux technology can impact alloy appearance

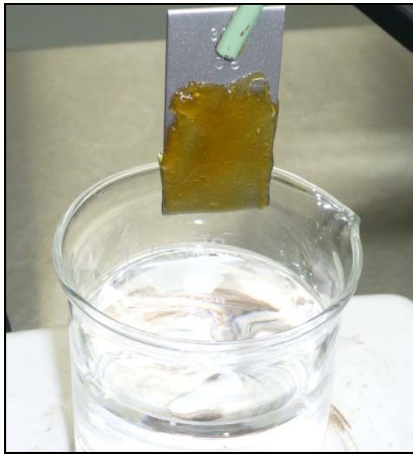


Soil Characterization

- What is the nature of the soil?
 - No Clean, Pb-free, Water Soluble, etc.
- What processing conditions can change the soil's cleaning properties?
 - Reflow, time before cleaning, etc.
- What tests are available to predict cleaning properties?
 - Solubility Parameters
 - Matching Cleaning Agent to Soil



Cleaning Rate



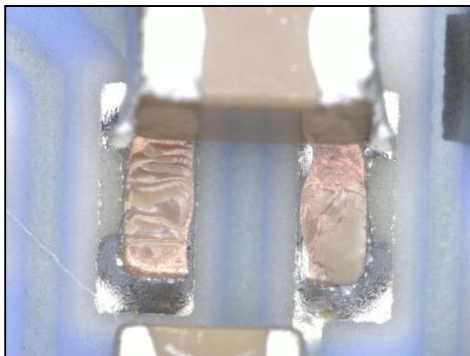
Static Cleaning Rate

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Dynamic Cleaning Rate

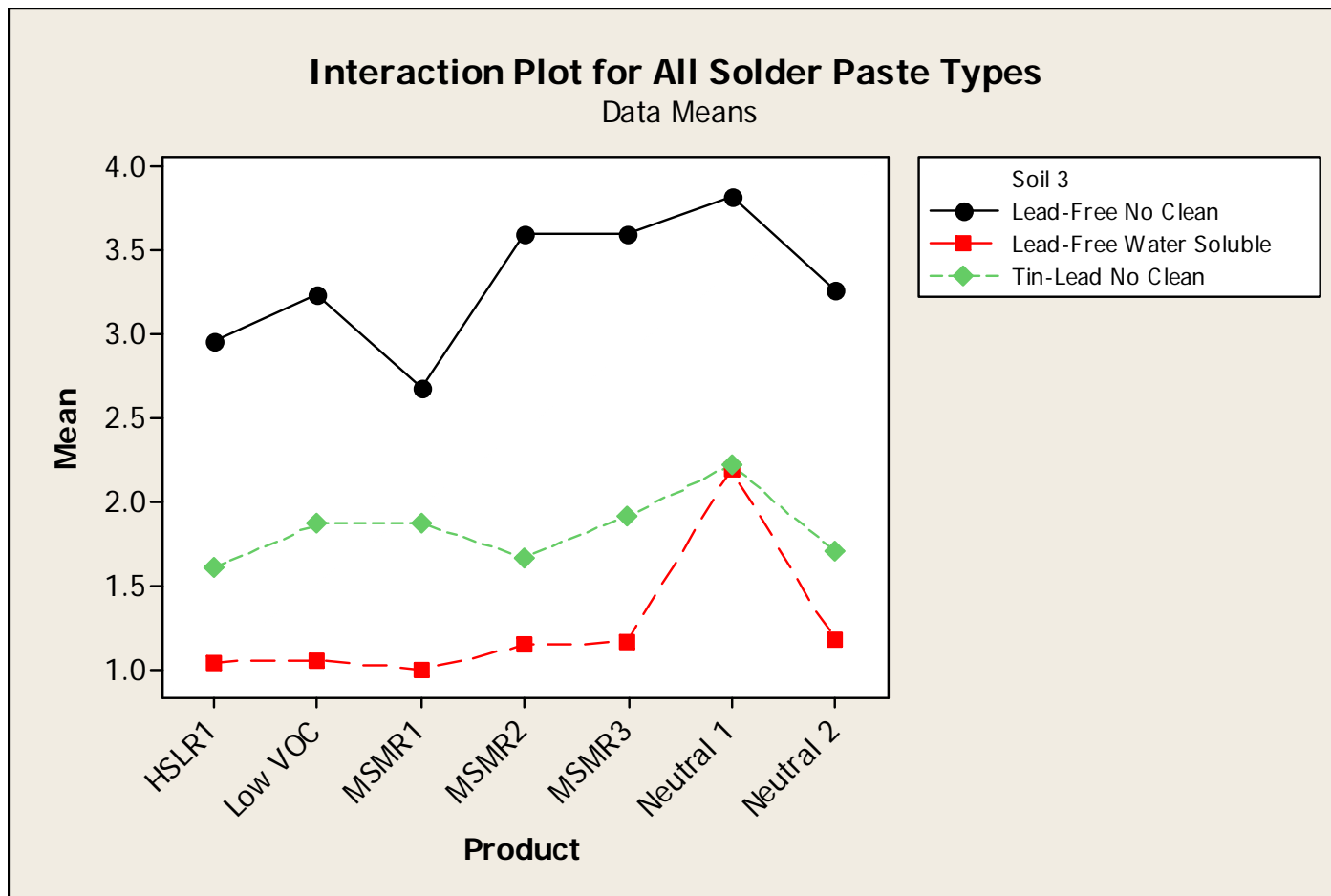
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Actual Cleaning Rate



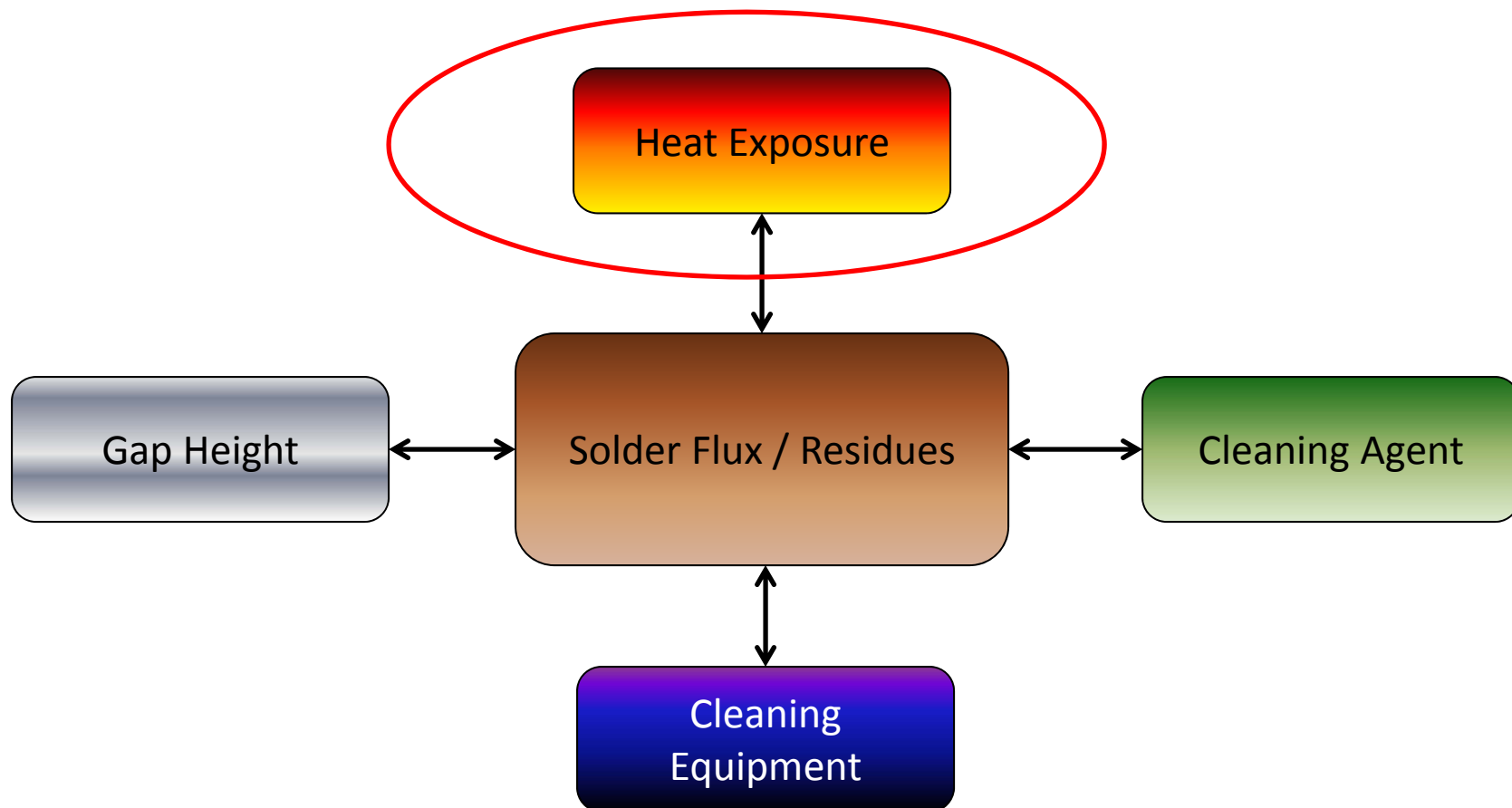


Static Cleaning Rate Comparisons





Factors Affecting Cleaning





Soil

- Critical to manage thermal exposure
 - Hard to remove flux residues result from
 - Long soak reflow profiles
 - Multiple reflow exposures
 - Bake cycles



Optimized Reflow



Overheating Reflow



Heat per Alloy

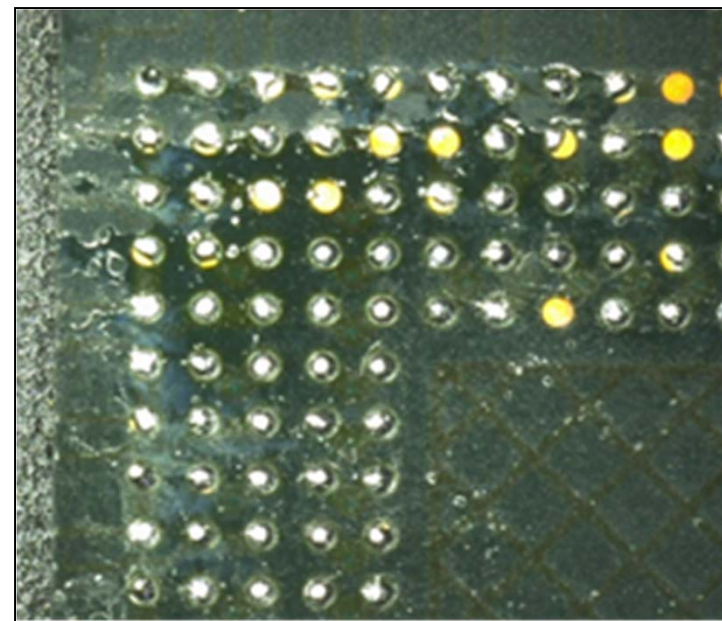
Flux	Alloy	Melting Temp (°C)	Peak Reflow (°C)	Cleaning Influence
RA	Sn 63.5/Ag 3.5	~180	~210	Easy
RA	SAC 305	221	~251	Typical
RA	Sn 5 / Pb 85 / Sb 10	245 - 255	~275 – 285	Difficult
RMA	Sn 63 / Pb 37	183	~213	Easy
WS	Sn 63 / Pb 37	183	~213	Easy
“HMP” RA	Sn 5 / 93.5 / 1.5	305 – 306	~335 – 336	Very Difficult
NC	Sn 96.5 / Ag 3.5	221	~251	Difficult

“HMP” = High Melting Point



Elevated Reflow Temperatures

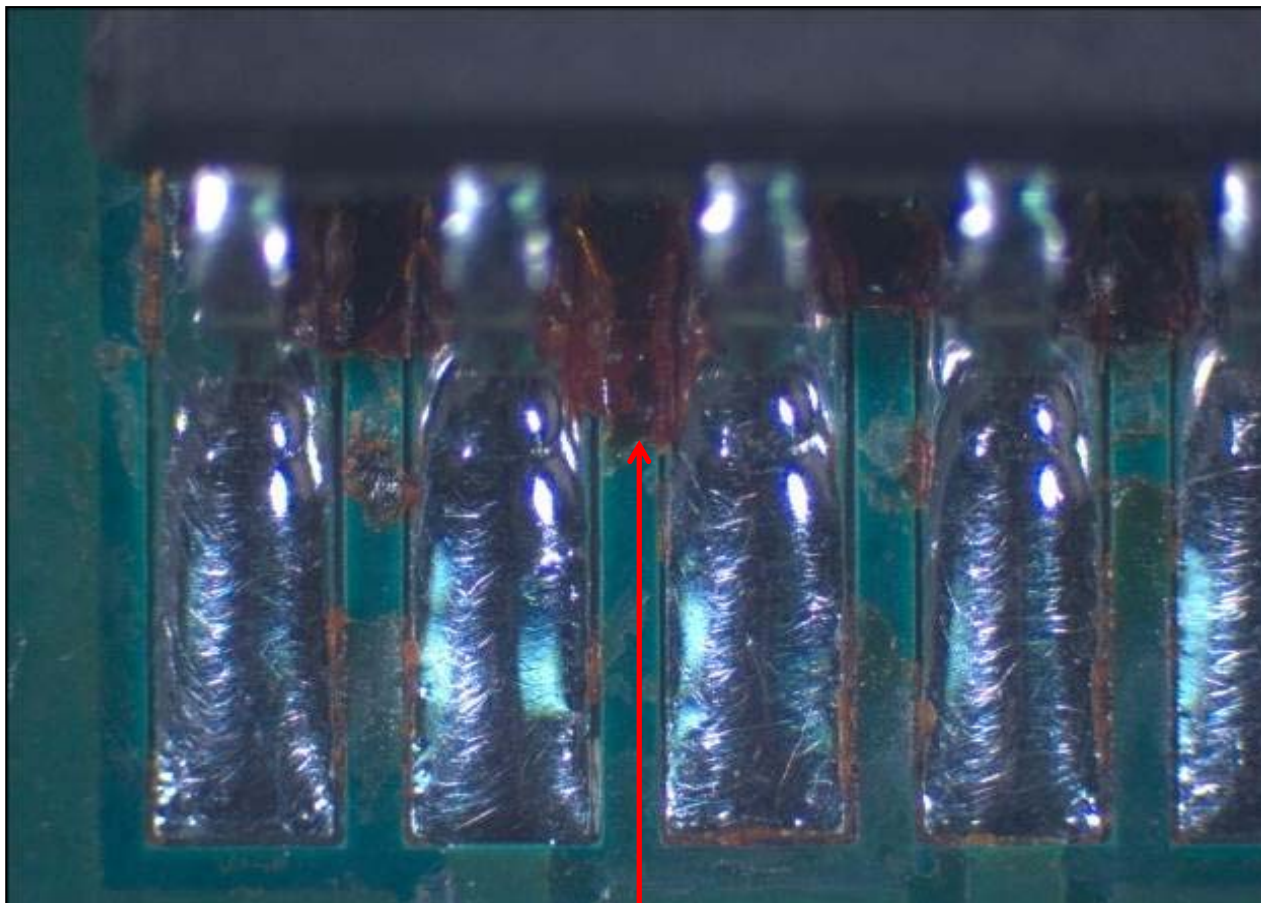
- Fluxes with higher molecular weight oxygen barrier
 - Withstand hotter temperatures
 - More difficult to clean
- Reduced Volatiles
 - Minimize voiding
 - Greater amount of residue
- More Oxidation Resistant
 - Reduce charring / burn off
 - Requires greater solvency & activity



μBGA with 0.40 mm pitch



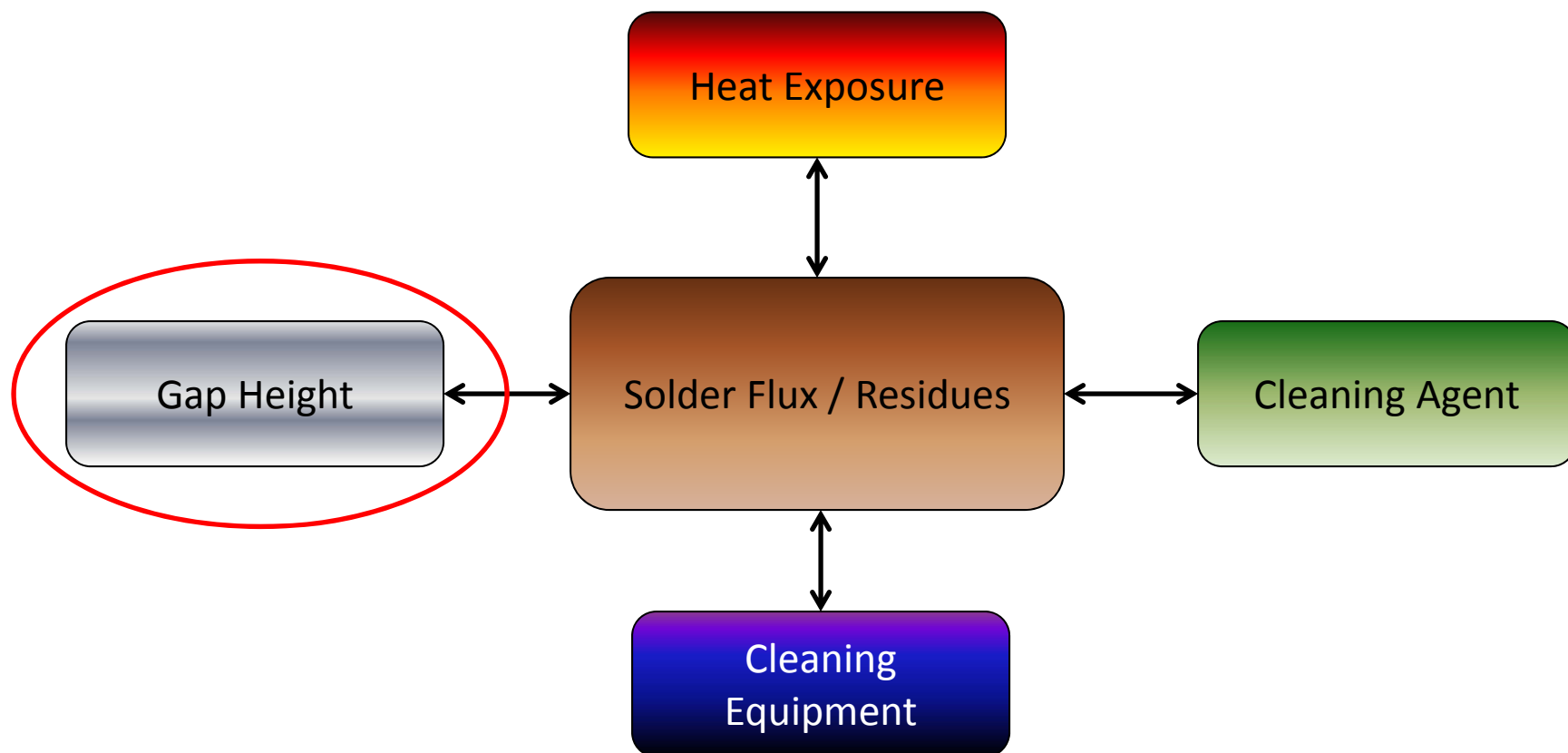
Char / Oxidize Residue



Burnt Flux Residue



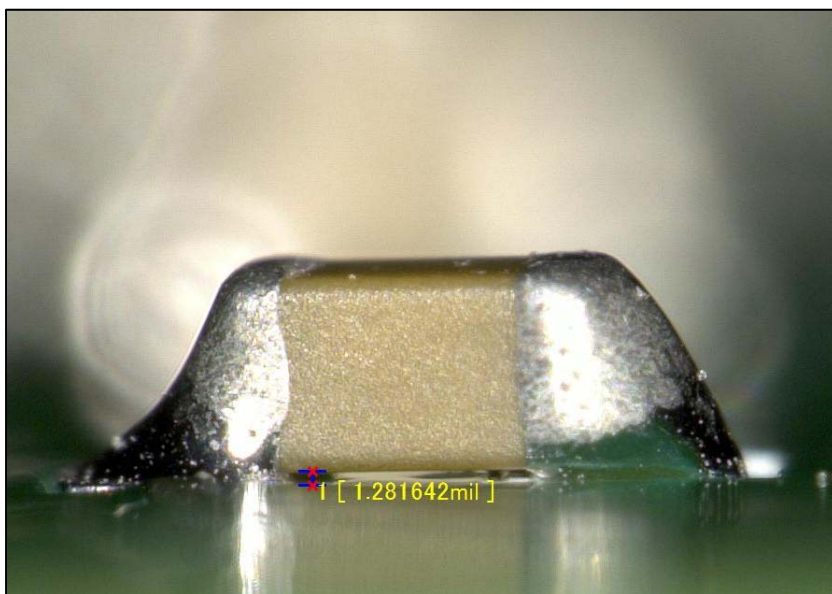
Factors Affecting Cleaning



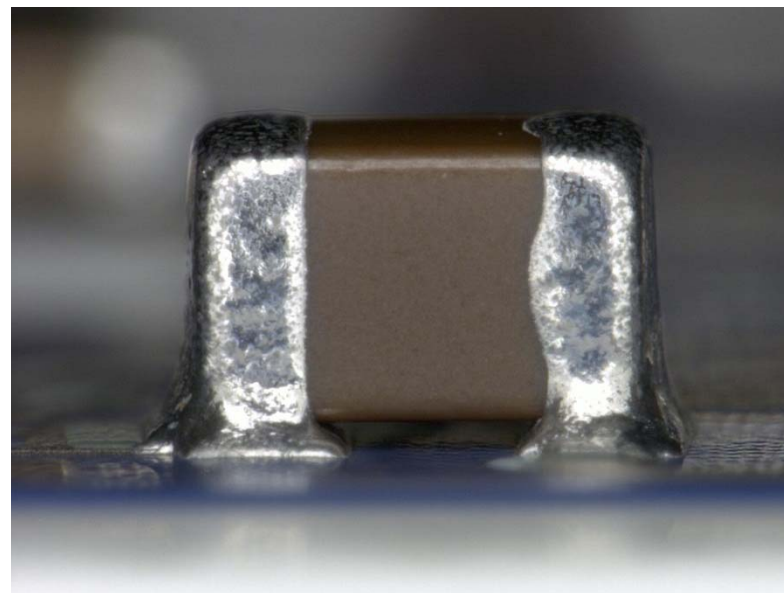


Chip Caps

- Gap Heights under 2 mils
- Flux bridges conductors



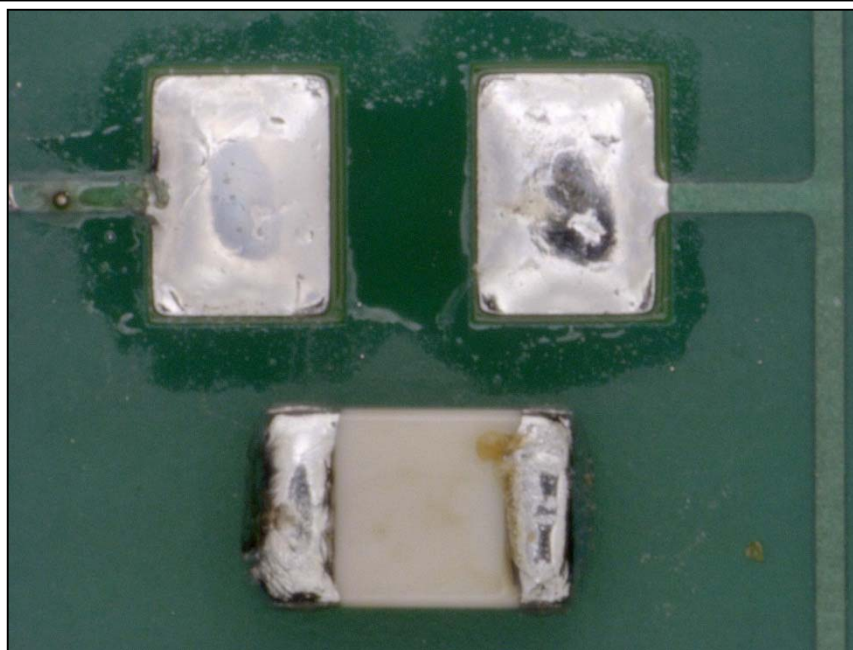
Low Gaps Require More Cleaning Time



High Gaps Require Less Cleaning Time



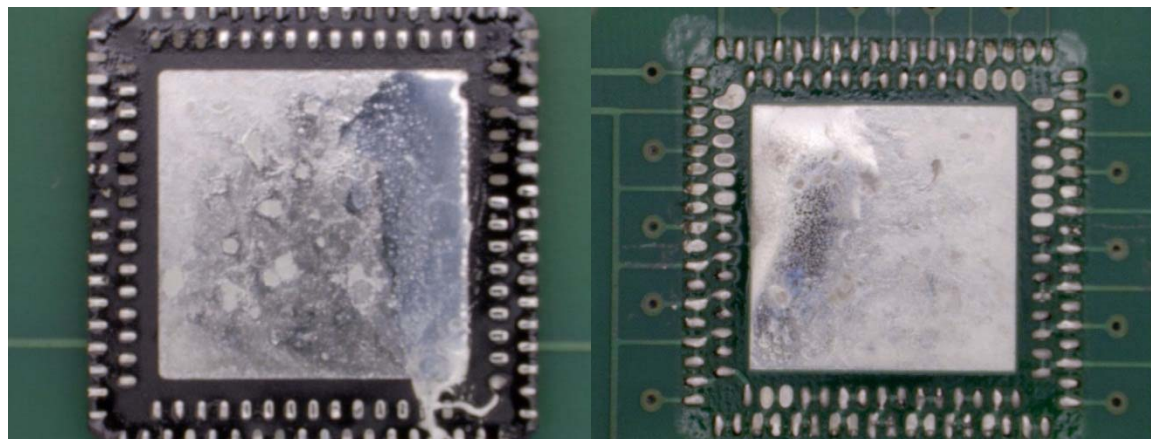
Flux Bridging / Underfill





QFN / MLF Components

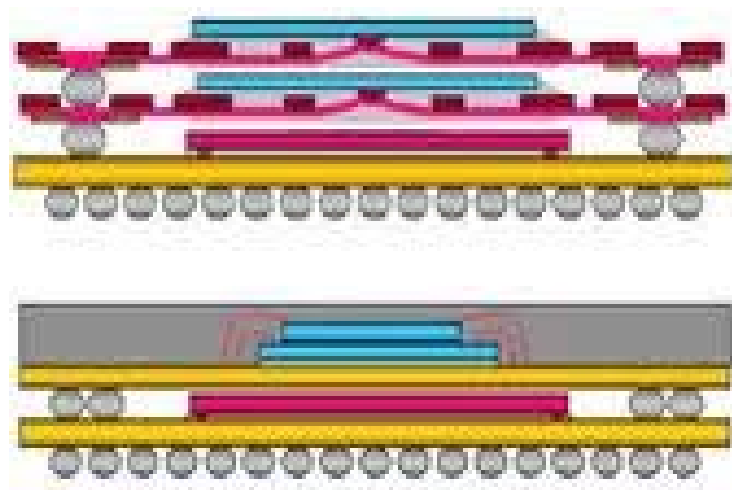
- Trapped flux under QFNs
 - No-clean flux residues are a risk due to
 - Non-activated weak organic acids
 - Partial cleaning exposes ionic residues
 - Water soluble flux residues
 - High levels of ionic residues





Advanced Packages

- BGAs, CSPs, WLPs and Flip Chip are under
 - Constant pressure to miniaturize
 - Lower cost
 - Put more packages or modules on the device

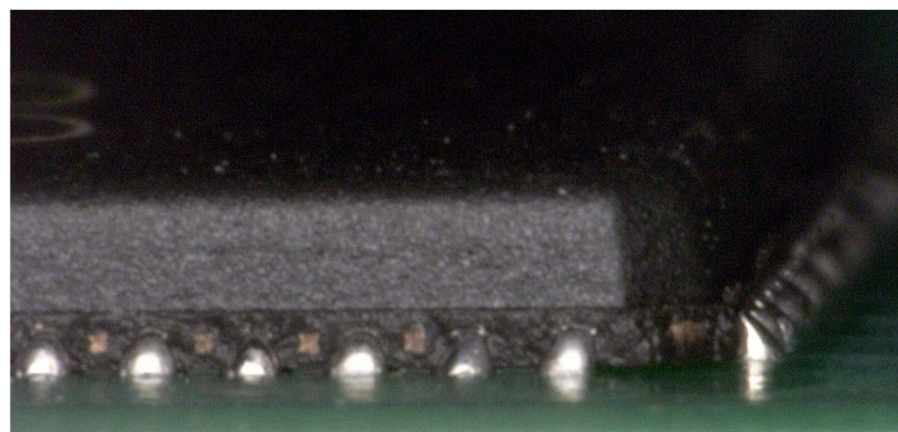
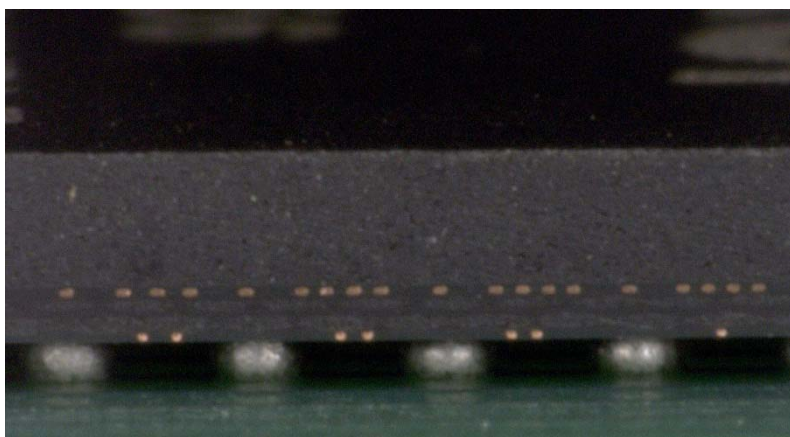


Package on Package



Z-Axis Comparison

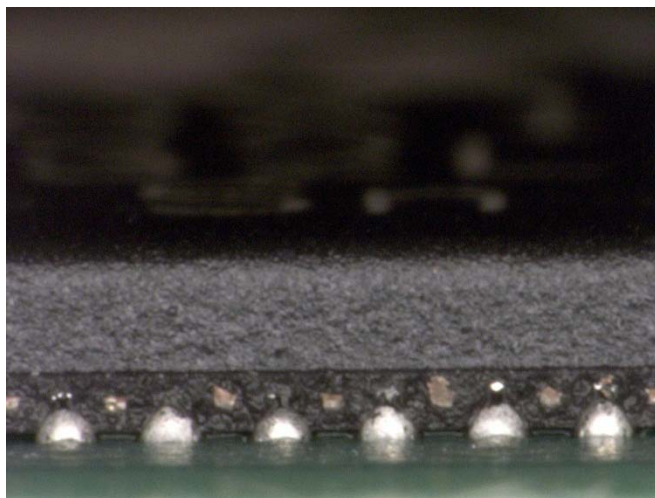
- BGA Components
 - 7-15 mil – good for cleaning
- Leadless Components
 - 1-5 mil – bad for cleaning





Z-Axis Concerns

- Electric Field = Voltage/Distance
 - Electric field increases
 - Digital technology as high as 0.5 volts/mil
 - Analog/power technology as high as 1.6 volt/mil
 - QFN as high as 3.5 volts/mil

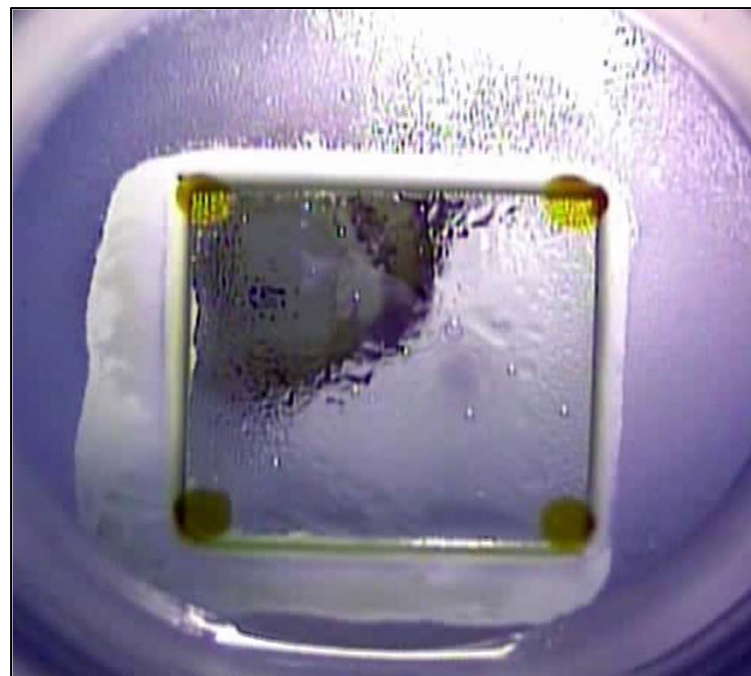


Trapped Residue Between Leads and Ground Pad



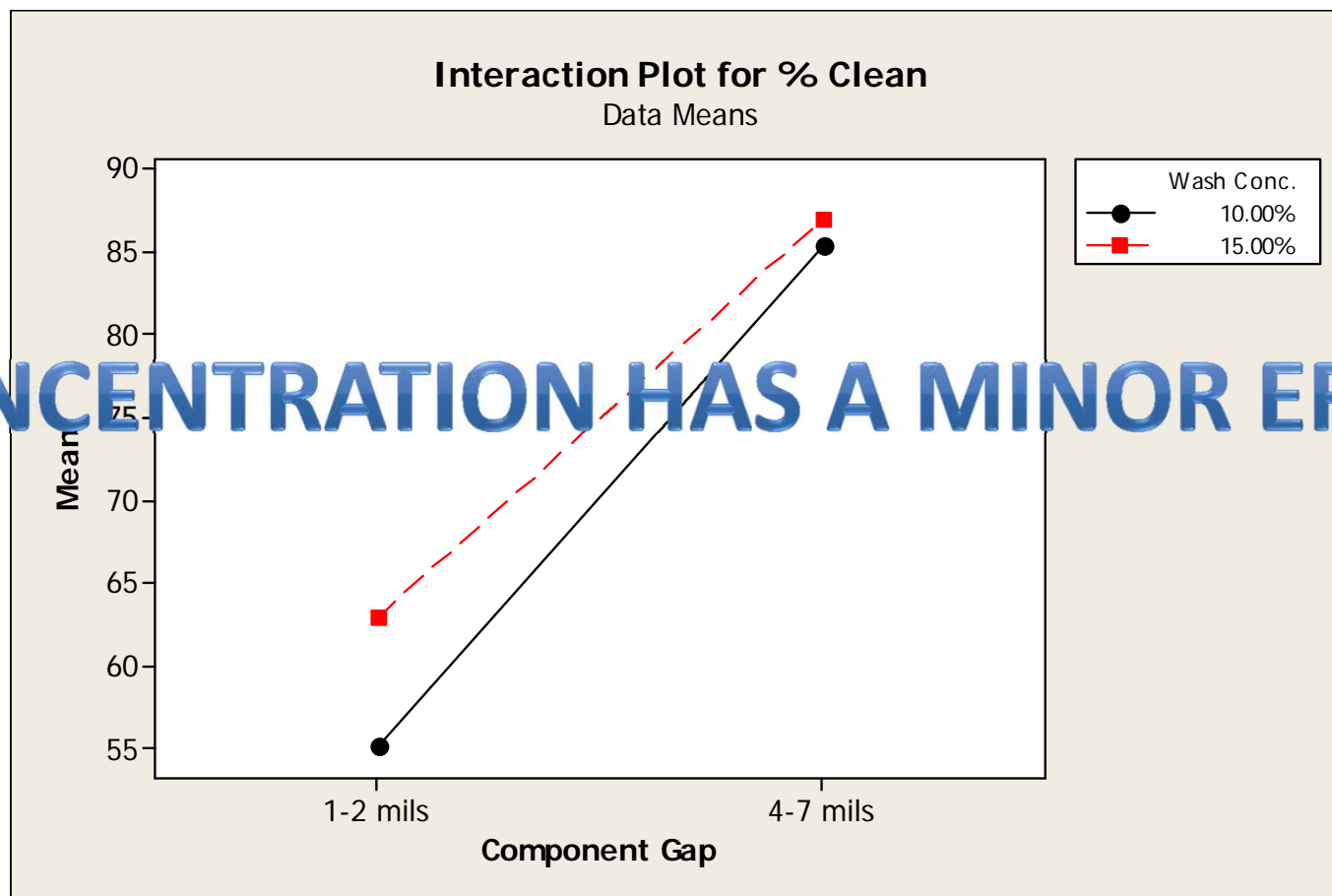
Gap Heights Magnify Cleaning Issues

- Flux underfills bottom termination devices
- To clean
 1. Wet soil +
 2. Dissolve soil +
 3. Break through soil +
 4. Create a flow channel =
 5. **Clean**





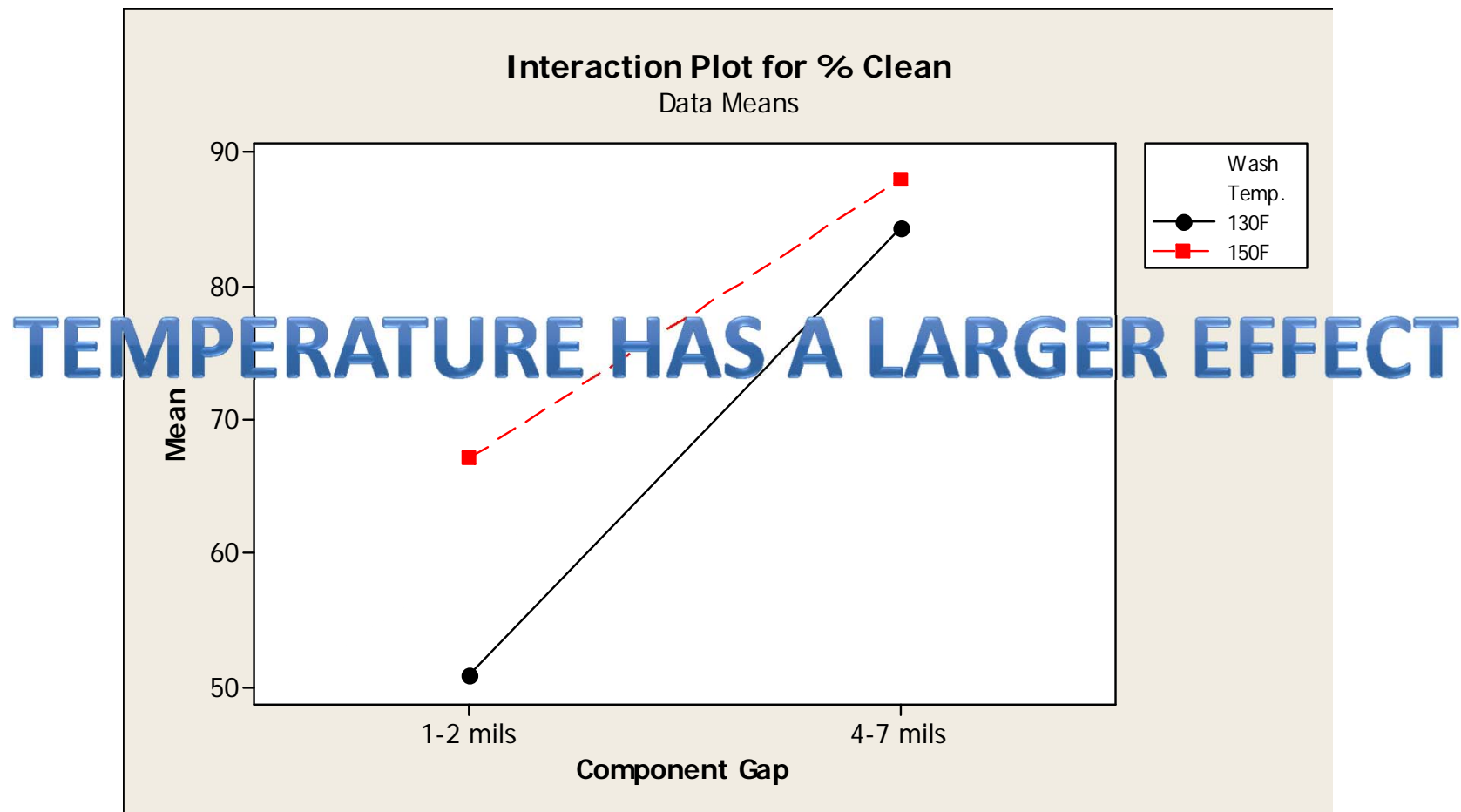
Wash Concentration



CONCENTRATION HAS A MINOR EFFECT

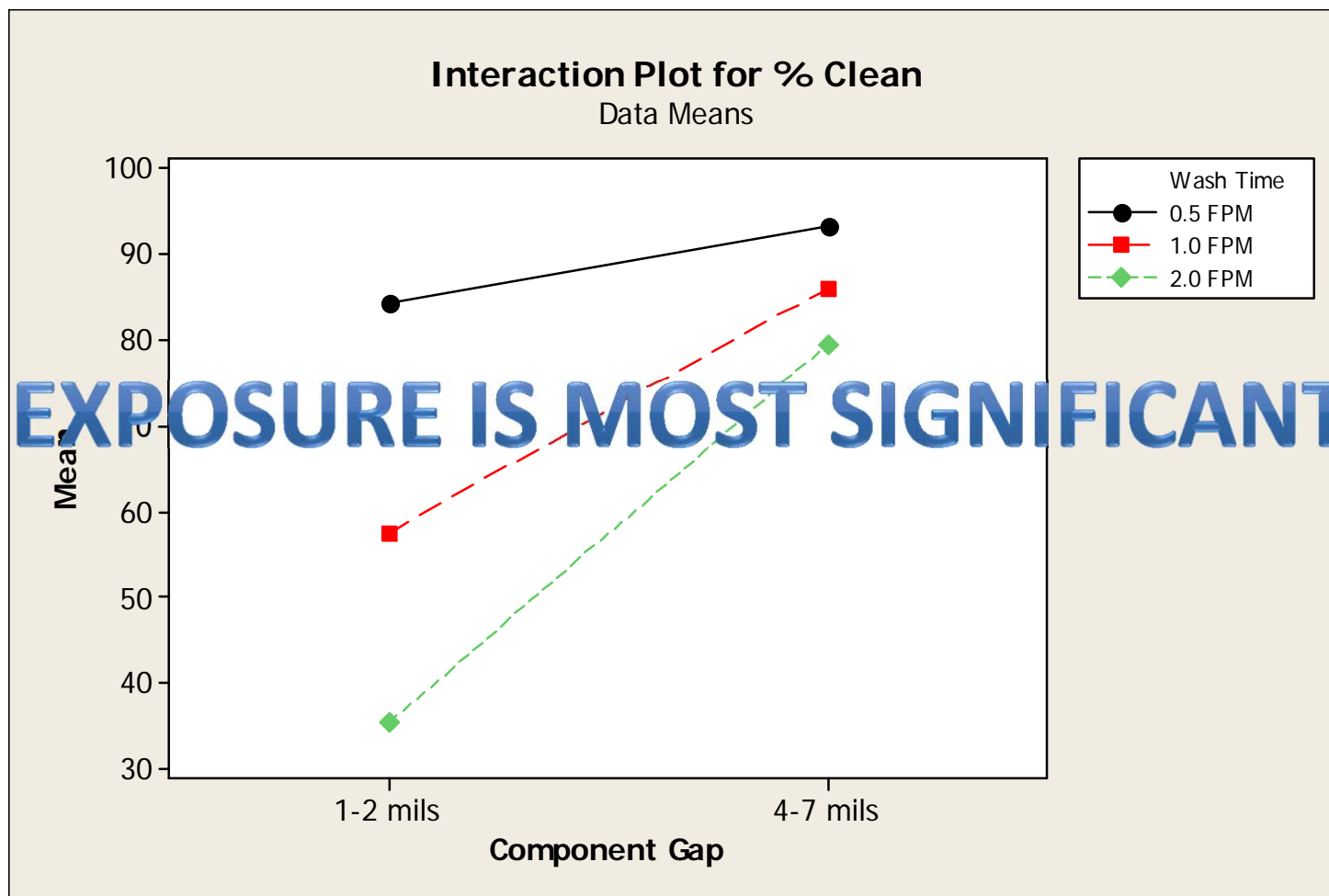


Wash Temperatures



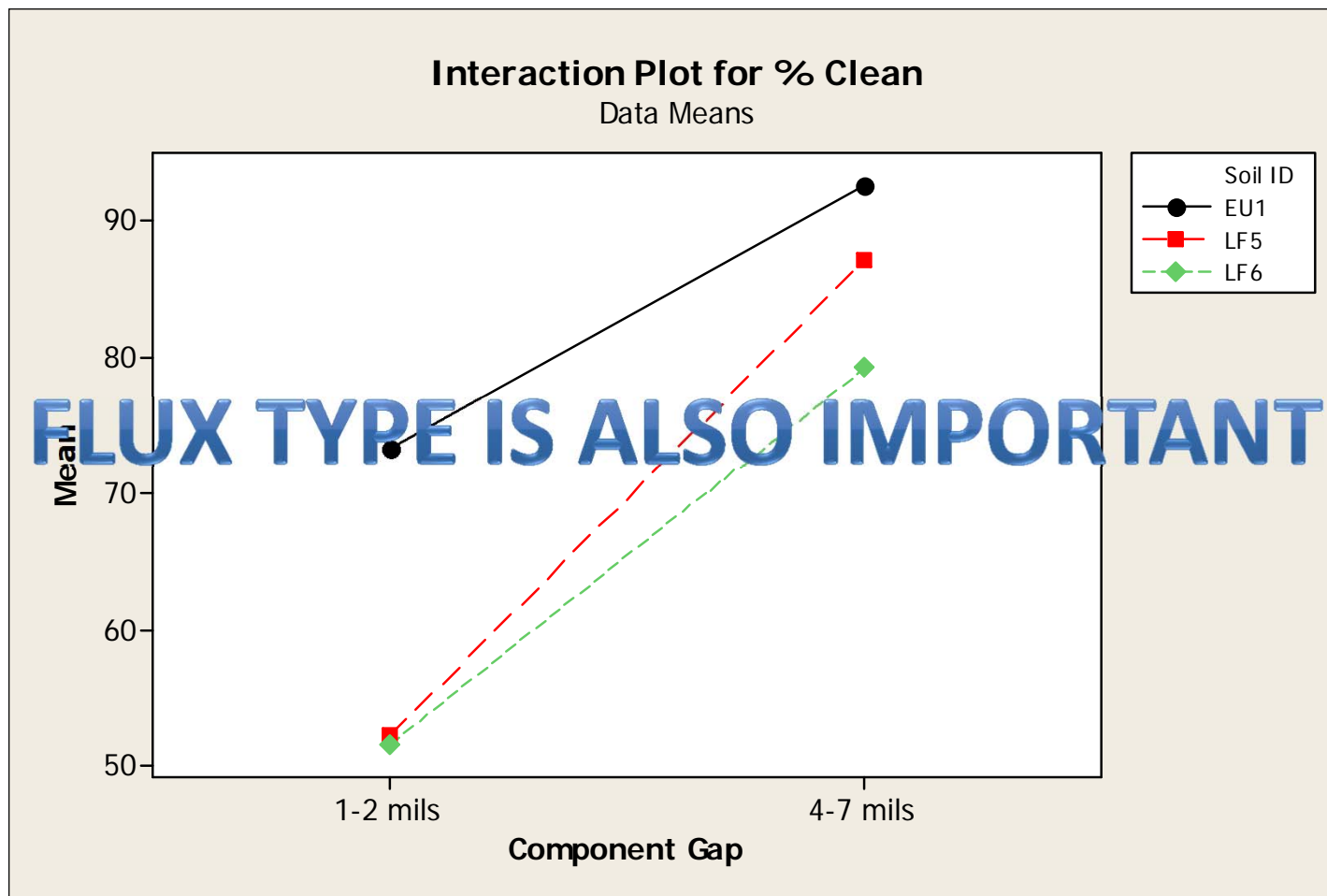


Wash Exposure Time



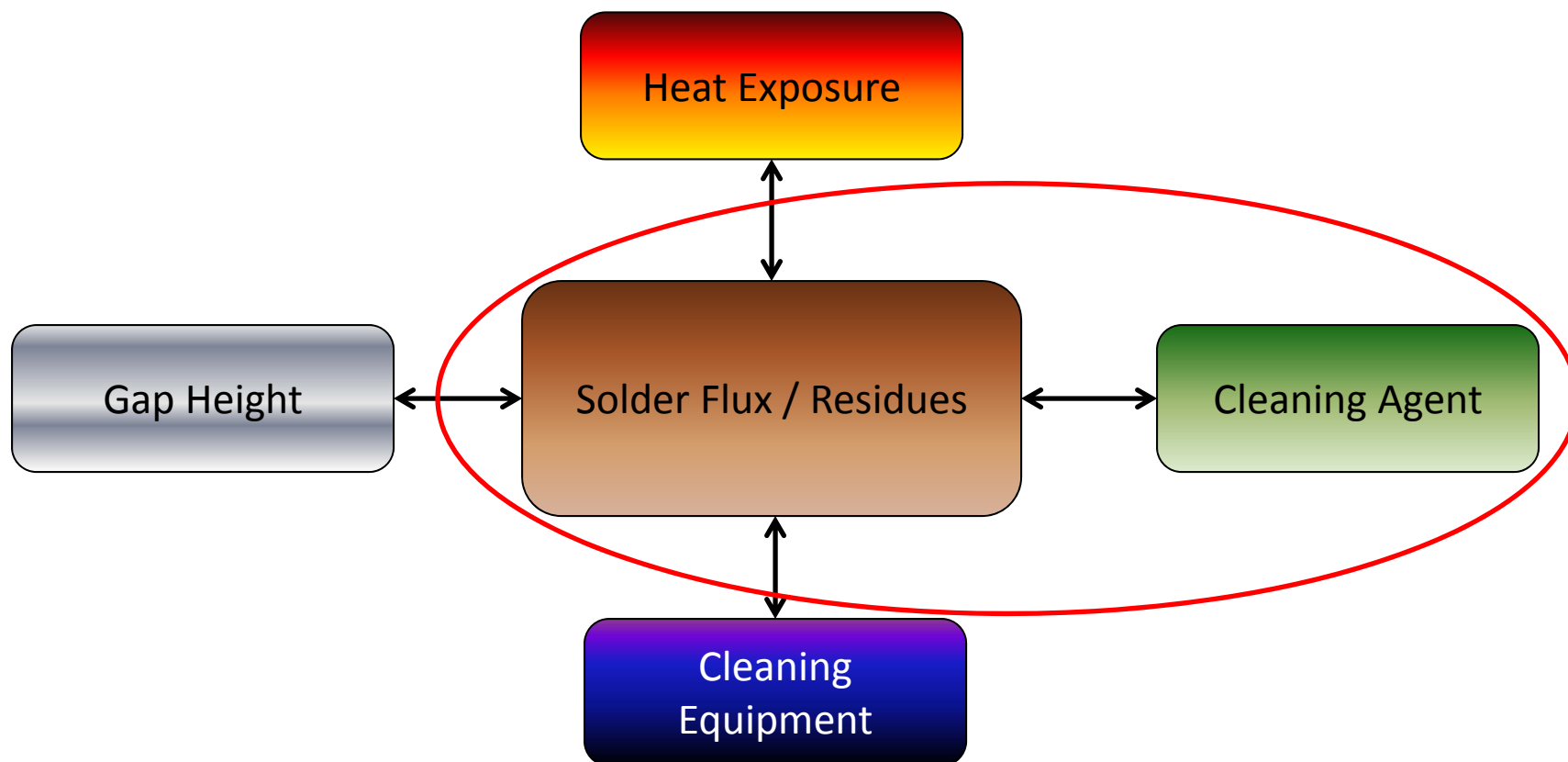


Solder Pastes





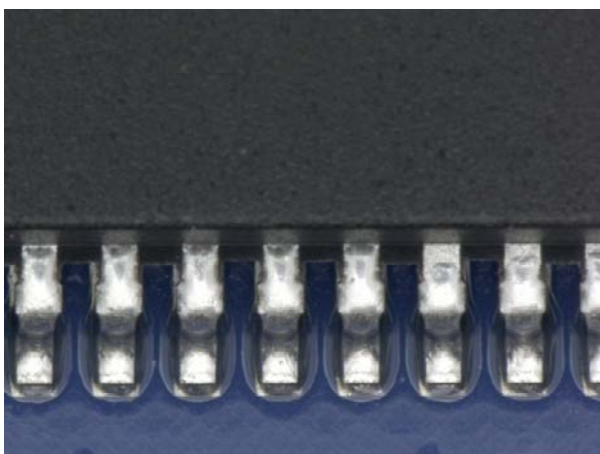
Factors Affecting Cleaning



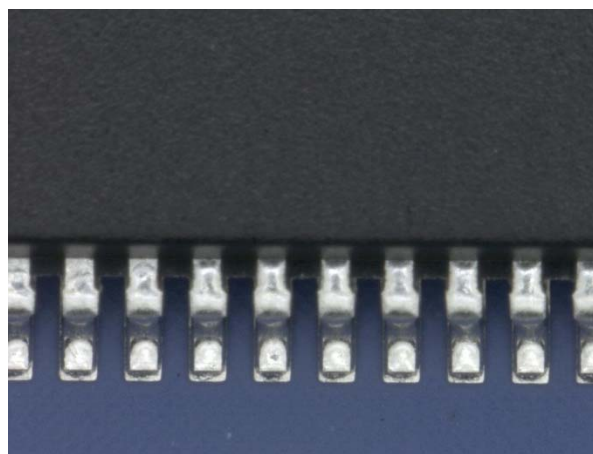


Cleaning Agent

- Must be matched to the flux residue/ soil
- Functional cleaning agents are
 - Engineered to the soil and cleaning equipment
 - Hydrophobic in nature to clean resinous soils
 - Hydrophilic in nature to clean polar soils



Before Cleaning



After Cleaning



Cleaning Agent Matched to Soil

Which will clean better?





Maximizing Static Rate

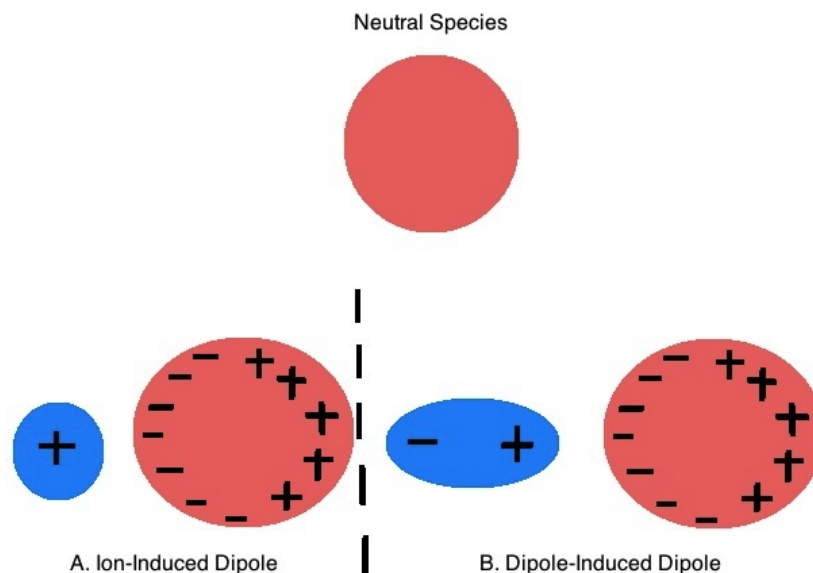
- Cleaning agent that dissolve the soil will be
 - Miscible / Dissolve in the cleaning agent
 - The basic principle ~ *Like Seeks Like*
- Key cleaning factors
 - Cleaning agent affinities (polar / ionic, covalent / non-ionic)
 - Kinetic surface energies





Cleaning No-Clean Flux

- Soils are made up of covalent resin structures
 - Polar covalent
 - Non-polar bond dipole
- Activators induce a dipole on flux resin
 - Improves dissolution
 - Removes harden residues





Significant Factors

- Process parameters
 - Cleaning agent
 - Wash concentration
 - Wash temperature
 - Wash time
 - Impingement energy





Wash Concentration

- Aqueous cleaning agents
 - Run at different dilution rates
 - Soil make-up influences concentration
 - Two phase cleaning fluids
 - Improves Hydrophobic /Hydrophilic balance
 - Lower concentration levels
 - Effective on covalent no-clean flux residues



Wash Temperature

- Rosin and resin flux residues
 - Soften at higher wash temperatures
 - As a general rule
 - The rate doubles for each 10°C (18°F) rise in temperature
 - On some residues, solubility is inverse to temperature
 - The chemical characteristics of the soil determine the actual wash temperature process window



Wash Time

- Wash time dependent on
 - Density of the assembly
 - BTC's require longer time to penetrate and clean
 - Gap Height ~ Lower takes longer time to clean
 - Flux residues ~ Harder residues increase cleaning time
 - Cleaning agent ~ Closer match reduces cleaning time
 - Impingement energy ~ Targeted energy reduces time



Impingement Energy

- Cleaning Agent + Impingement Energy = Clean
 - Low energy machines require longer cleaning time
 - Low energy may be insufficient to penetrate gaps
 - Strong impingement energy reduces cleaning time
 - Spray-in-air using tighter spray patterns
 - Ultrasonic cleaning energy

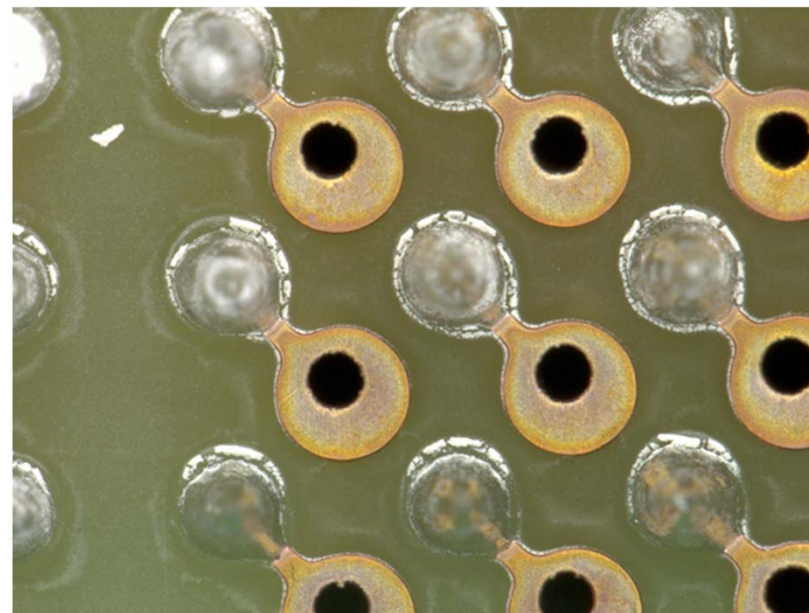
ONE CLEANING AGENT FOR ALL APPLICATIONS IS MORE CHALLENGING

- Cleaning agent #1
 - Cleans fast, impacted sensitive high-lead alloys
- Cleaning agent #2
 - Didn't clean as well, but solder joints were better
- Cleaning agent #3
 - Cleaned better than #2, still affected solder after longer / multiple exposures
- Cleaning agent #4
 - Best looking solder, slowest to clean
 - Especially on the high temp alloys



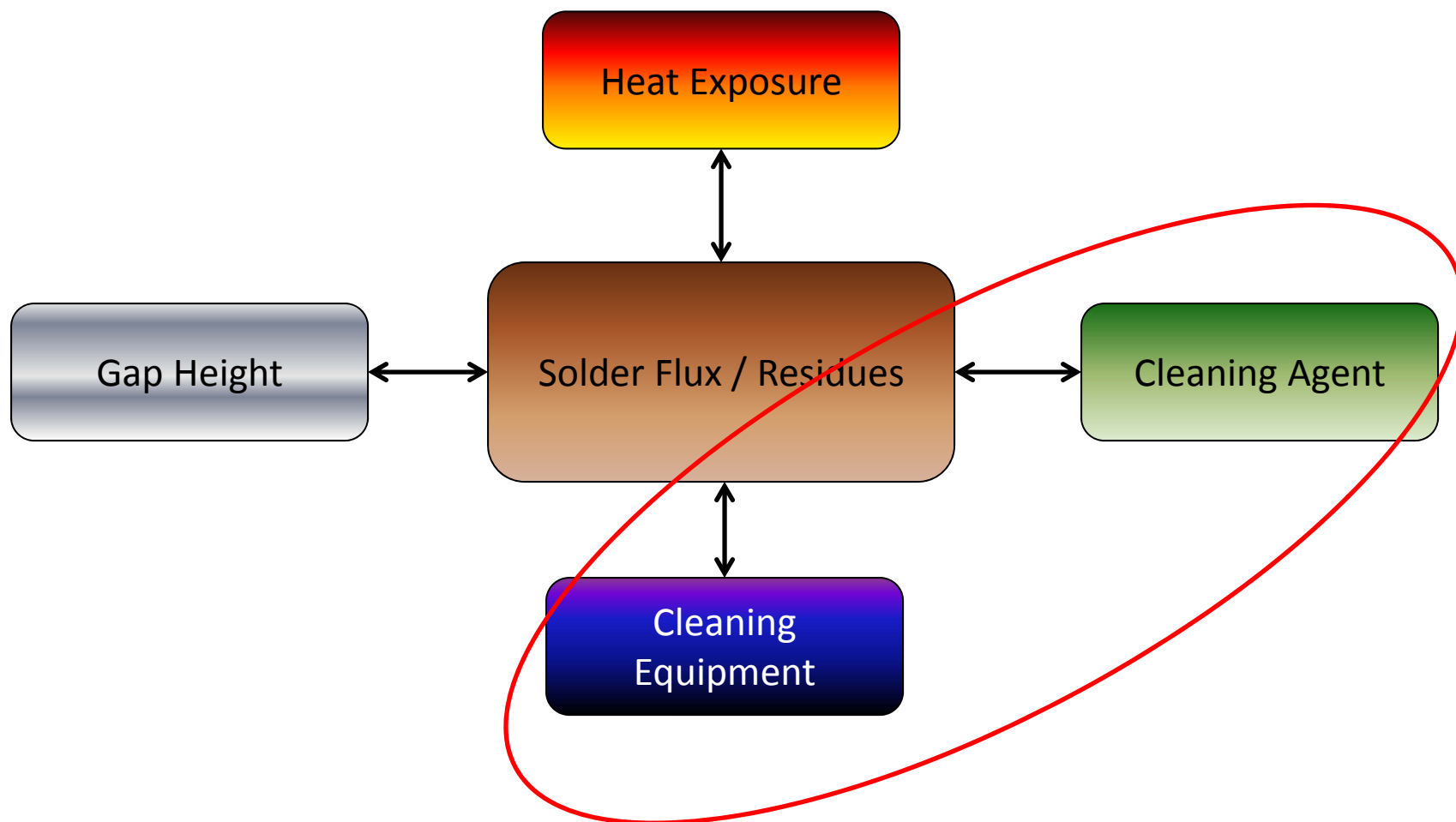
Poorly Match Cleaning Agent

- A poorly matched cleaning agent will not
 - Remove the residue
 - Even in the presence of mechanical energy
 - Remove partial levels of the flux residue
 - White residue
 - Expose activators and metallic salts



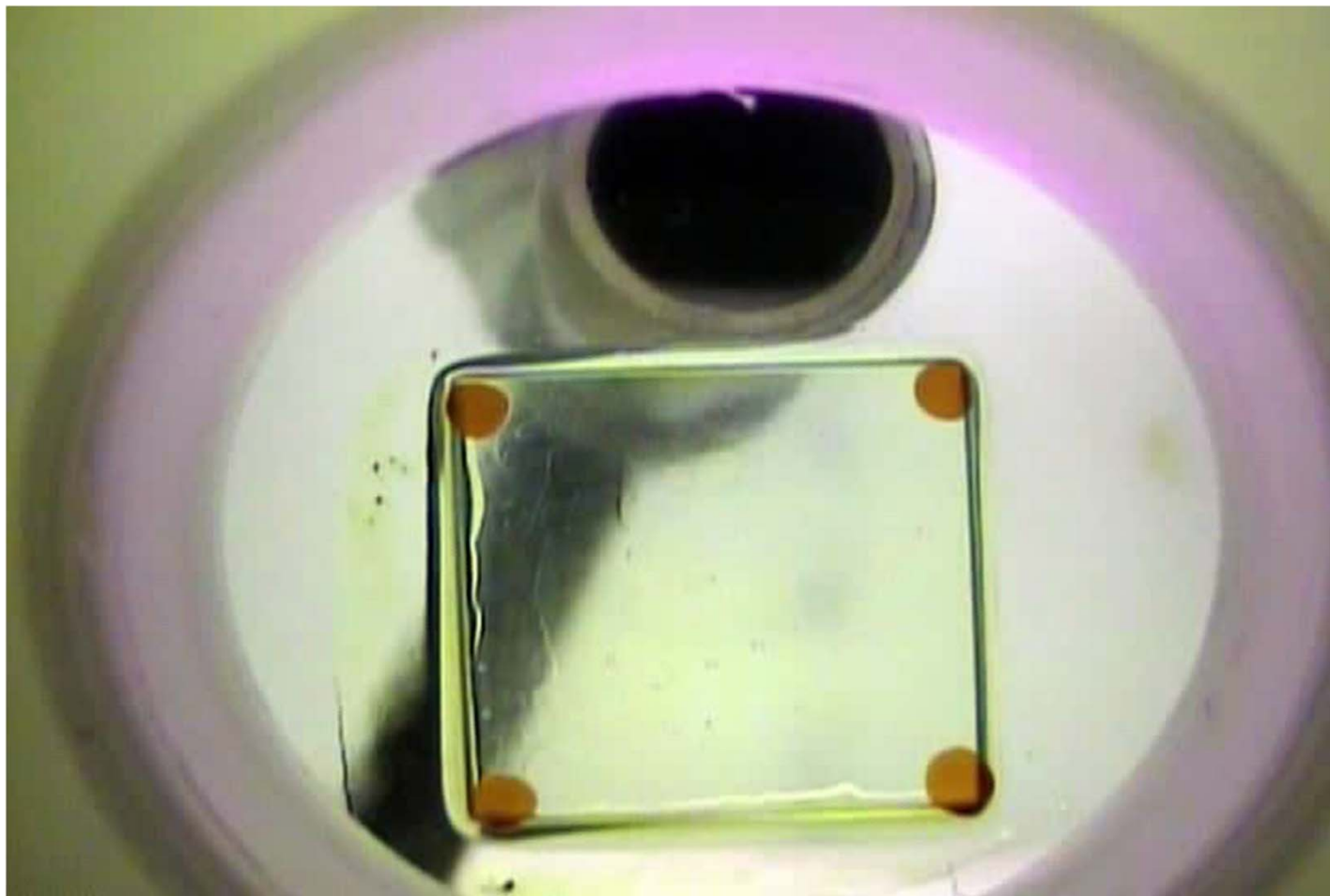


Factors Affecting Cleaning



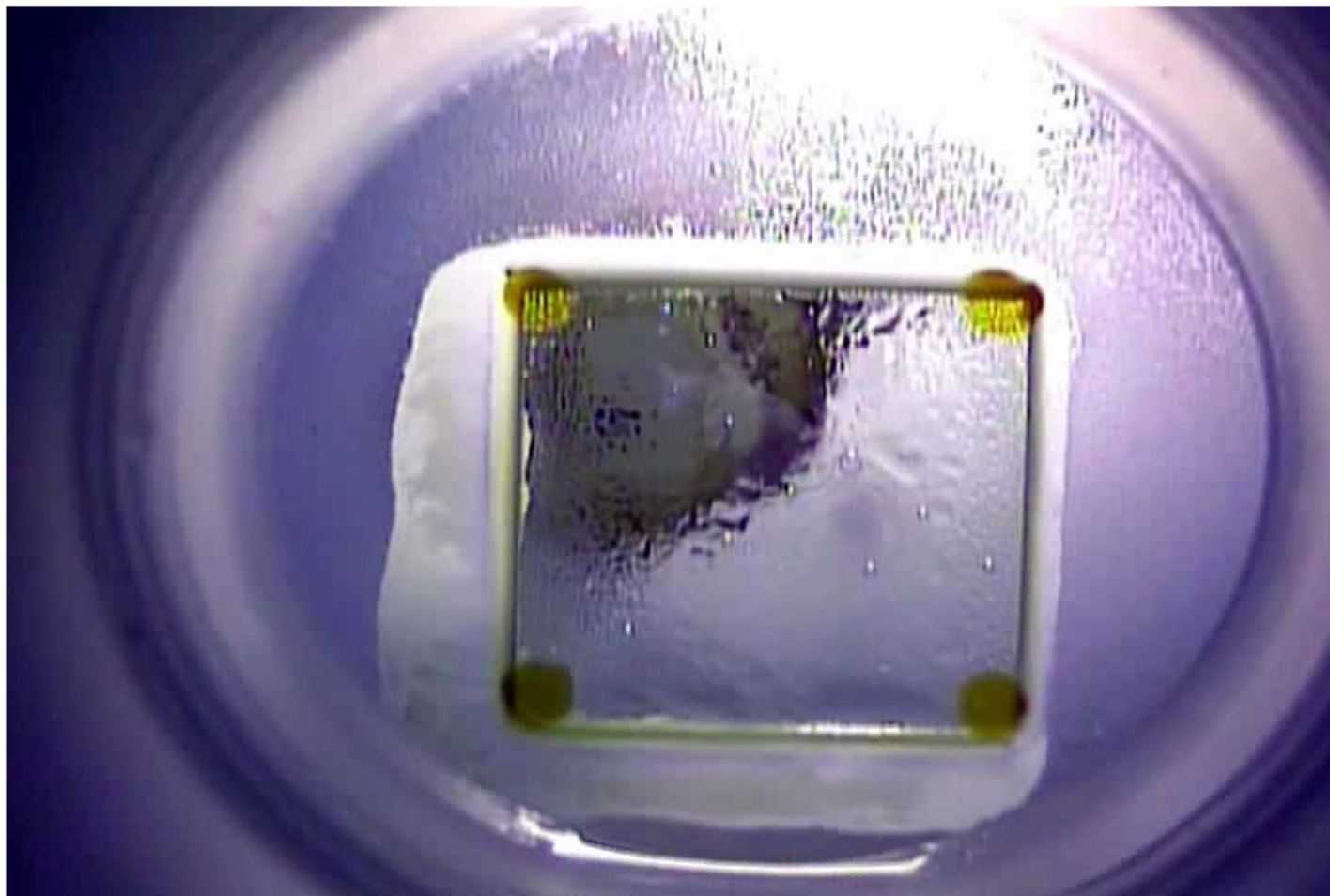


Low Pressure



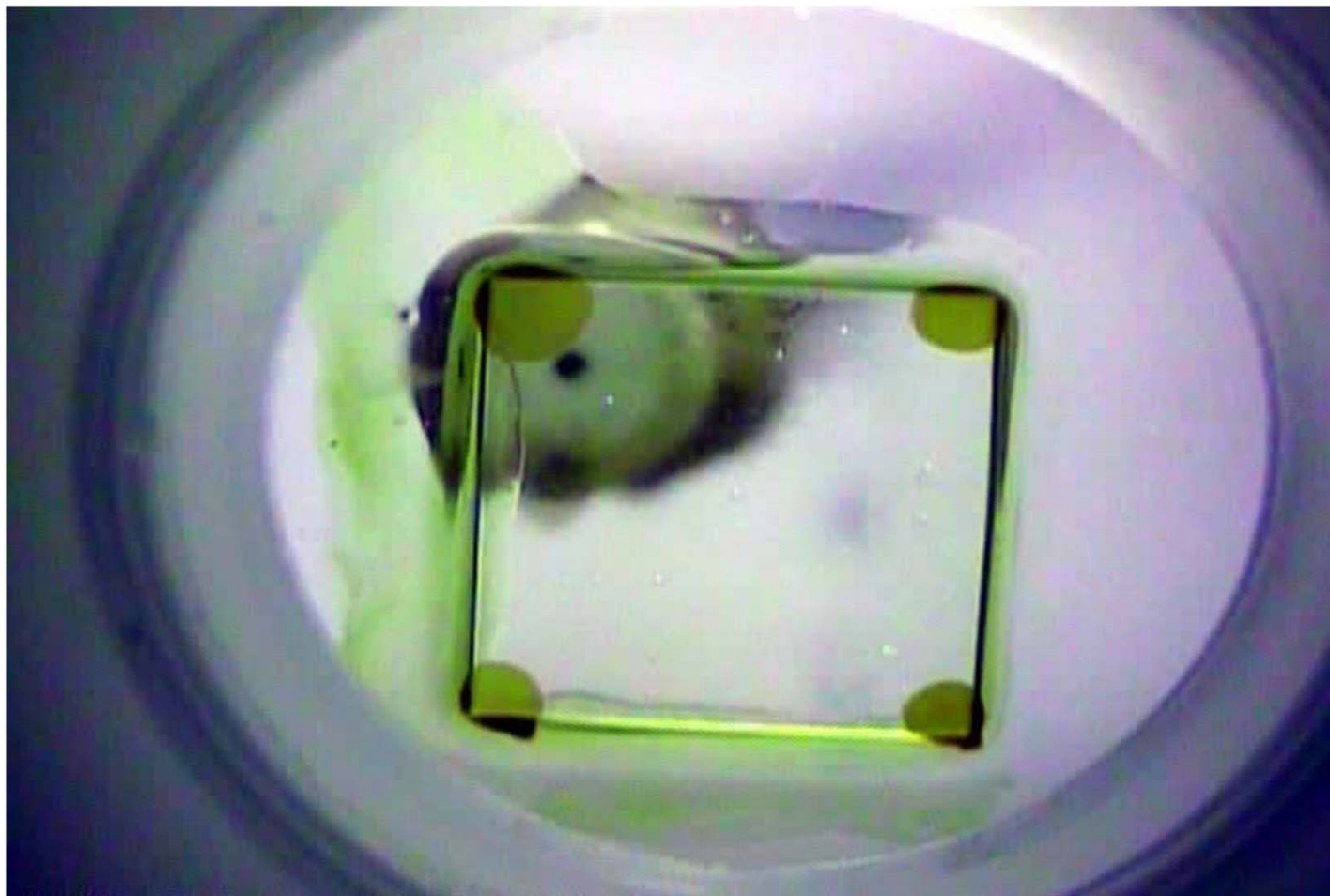


Soft Residue



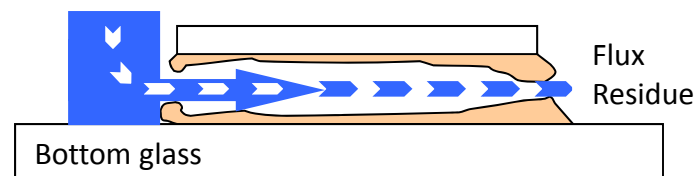
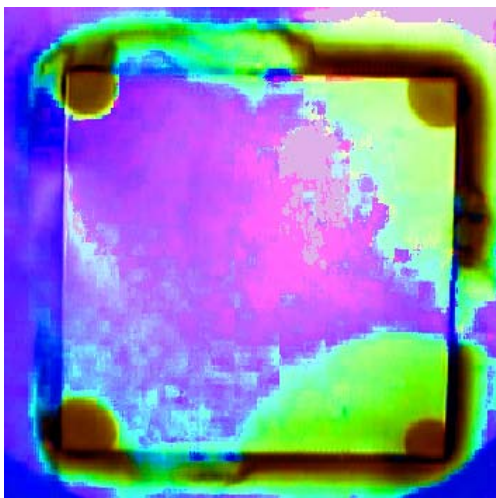


Hard Residue





Observed Cleaning Propagation



- Cleaning Channels develop in “solvent rich” out gassing channels



Fluid Delivery

- Flow Rate
 - Direct effect on droplet size
 - Increased flow rate increases droplet rate
- Pressure
 - Has an inverse effect on droplet size
 - An increase in pressure will reduce droplet size
- Spray Angle
 - Has an inverse effect on droplet size
 - An increase in spray angle reduces droplet size



Spray System Nozzle Design

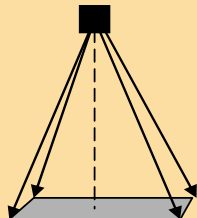
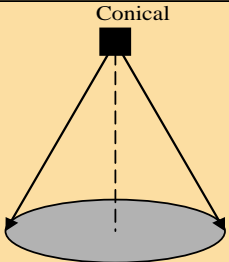

➤ Four variables determine Impact pressure

- Nozzle type
- Distance
- Manifold pressure
- Fluid Density



Source: Stach & Bixenman (2005). SMTAI.

8/21/2012

Spray Type	Typical pressure @ 2",50psi man. /Pressure loss/in	Indicated use
<p>Fan/Delta</p> 	2 psi / ~50% drop/inch	Wide coverage, overlap for high impingement or close work distance
<p>Conical</p> 	0.4 psi / ~75% drop/inch	Widest coverage area, lowest kinetic energy, flooding applications
<p>Coherent</p> 	10 psi / ~10% drop/inch	Smallest coverage, highest energy density over longest distance

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Spray Nozzle Pressure Measured at Board Surface

Manifold Pressure	Flow: (gpm)	Impingement (psi) @			Coverage width (in)@	
0.075" Coherent Jet		1"	2"	4"	1.5"	4.0"
30 psig	0.69	15	10	6.5	0.6	0.7
40 psig	0.82	17	12	8	0.6	0.7
50 psig	0.89	19	13	9.5	0.6	0.8
60 psig	0.97	20	15	11	0.6	0.8
F40-1.0 Fan Nozzle						
30 psig	0.89	3.2	1.6	0.2	1.5	3.25
40 psig	1.06	4.4	1.8	0.3	1.7	3.60
50 psig	1.20	6.0	2.3	0.5	1.7	4.0
60 psig	1.30	7.2	2.5	0.5	1.8	4.0

Source: Stach & Bixenman (2005). SMTAI.



F40-1.0 Fan Nozzle



60 PSI



100 PSI



0.75 Coherent Jet



60 PSI



100 PSI

CONCLUSIONS



Cleaning BGAs

- Pose new challenges
- Requires
 - Tighter process controls
 - More rigorous attention to process design
 - Developing process control windows
 - Implement the process using proper test methods



Inadequate Cleaning Practices

- Can cause severe failures
 - Products that fail in the field
- Lead-free soldering is
 - More challenging to clean
 - Fluxes are more difficult to remove
 - Higher molecular weight
 - Polymers
 - Increased temperature
 - Miniaturization
- Plan for these changes during process design



Circuit Board Design

- Plays an important role for cleaning
- Key considerations
 - Density of components
 - Component layout
 - Thermal heat requirements
- From a cleanability perspective
 - Bottom termination component selection
 - Solder mask definition
 - Placement and layout influence the clearance gaps
 - Higher standoff gaps improve cleaning and reduce time



Contact Information

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Thank You!

